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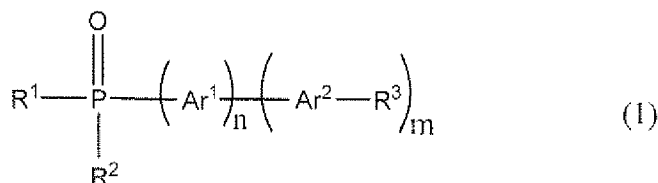
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(54) **ORGANIC SEMICONDUCTIVE LAYER COMPRISING PHOSPHINE OXIDE COMPOUNDS**

(57) The present invention relates to an organic semiconductive layer which is an electron transport layer and/or an electron injection layer and/or an n-type charge generation layer, the organic semiconductive layer comprising at least one compound of formula (1)



wherein R¹ and R² are each independently selected from C₁ to C₁₆ alkyl; Ar¹ is selected from C₆ to C₁₄ arylene or C₃ to C₁₂ heteroarylene; Ar² is independently selected from C₁₄ to C₄₀ arylene or C₈ to C₄₀ heteroarylene; R³ is independently selected from H, C₁ to C₁₂ alkyl or C₁₀ to C₂₀ aryl; wherein each of Ar¹, Ar² and R³ may each independently be unsubstituted or substituted with at least one C₁ to C₁₂ alkyl group; n is 0 or 1; and m is 1 in case of n = 0; and m is 1 or 2 in case of n = 1, phosphine oxide compounds comprised therein and to organic electroluminescent devices comprising such layers and compounds.

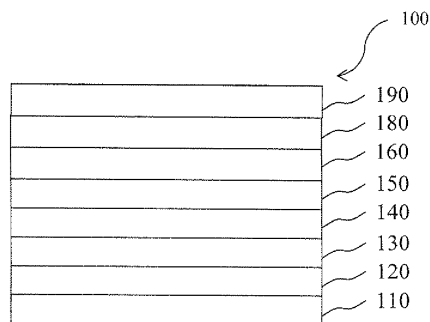


Fig.1

Description

[0001] The present invention relates to an organic semiconductive layer, a phosphine oxide compound comprised therein, and to an organic electroluminescent device.

DESCRIPTION OF THE RELATED ART

[0002] Organic light-emitting diodes (OLEDs), which are self-emitting devices, have a wide viewing angle, excellent contrast, quick response, high brightness, excellent driving voltage characteristics, and color reproduction. A typical OLED includes an anode, a hole transport layer (HTL), an emission layer (EML), an electron transport layer (ETL), and a cathode, which are sequentially stacked on a substrate. In this regard, the HTL, the EML, and the ETL are thin films formed from organic and / or organometallic compounds.

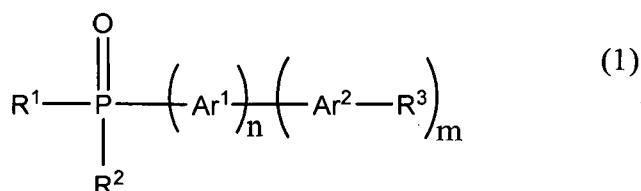
[0003] When a voltage is applied to the anode and the cathode, holes injected from the anode electrode move to the EML, via the HTL, and electrons injected from the cathode electrode move to the EML, via the ETL. The holes and electrons recombine in the EML to generate excitons. When the excitons drop from an excited state to a ground state, light is emitted. The injection and flow of holes and electrons should be balanced, so that an OLED having the above-described structure has excellent efficiency.

[0004] However, there is a continuous need to improve the performance of OLEDs, in particular matrix compounds in the electron transport layer, electron injection layer and n-type charge injection layer which enable high efficiency, low operating voltage and excellent stability.

SUMMARY

[0005] Therefore, it is the object of the present invention to provide organic electroluminescent devices and novel compounds for use therein overcoming drawbacks of the prior art, in particular featuring reduced operating voltage and/or improved external quantum efficiency (EQE) and/or improved lifetime in OLEDs, in particular in fluorescent blue devices.

[0006] This object is achieved by an organic semiconductive layer which is an electron transport layer and/or an electron injection layer and/or an n-type charge generation layer, the organic semiconductive layer comprising at least one compound of formula (1)



wherein R^1 and R^2 are each independently selected from C_1 to C_{16} alkyl;

Ar^1 is selected from C_6 to C_{14} arylene or C_3 to C_{12} heteroarylene;

Ar^2 is independently selected from C_{14} to C_{40} arylene or C_8 to C_{40} heteroarylene;

R^3 is independently selected from H, C_1 to C_{12} alkyl or C_{10} to C_{20} aryl;

wherein each of Ar^1 , Ar^2 and R^3 may each independently be unsubstituted or substituted with at least one C_1 to C_{12} alkyl group;

n is 0 or 1; and

m is 1 in case of $n = 0$; and m is 1 or 2 in case of $n = 1$.

It may be further preferred that the C_{14} to C_{40} arylene or C_8 to C_{40} heteroarylene, which is a possible selection for Ar^2 , comprises a conjugated system of at least 10 delocalized electrons.

[0007] In this regard, the term "conjugated system" shall be understood as a system of different aromatic moieties

(such as phenyl rings) connected with each other either to form condensed aromatic systems (such as naphthyl groups) or being connected with each other only by single bonds (such as biphenyl groups). Exemplary embodiments of respective conjugated systems of at least 10 delocalized electrons, which are a preferred selection for Ar^2 , are represented by the following formulas.

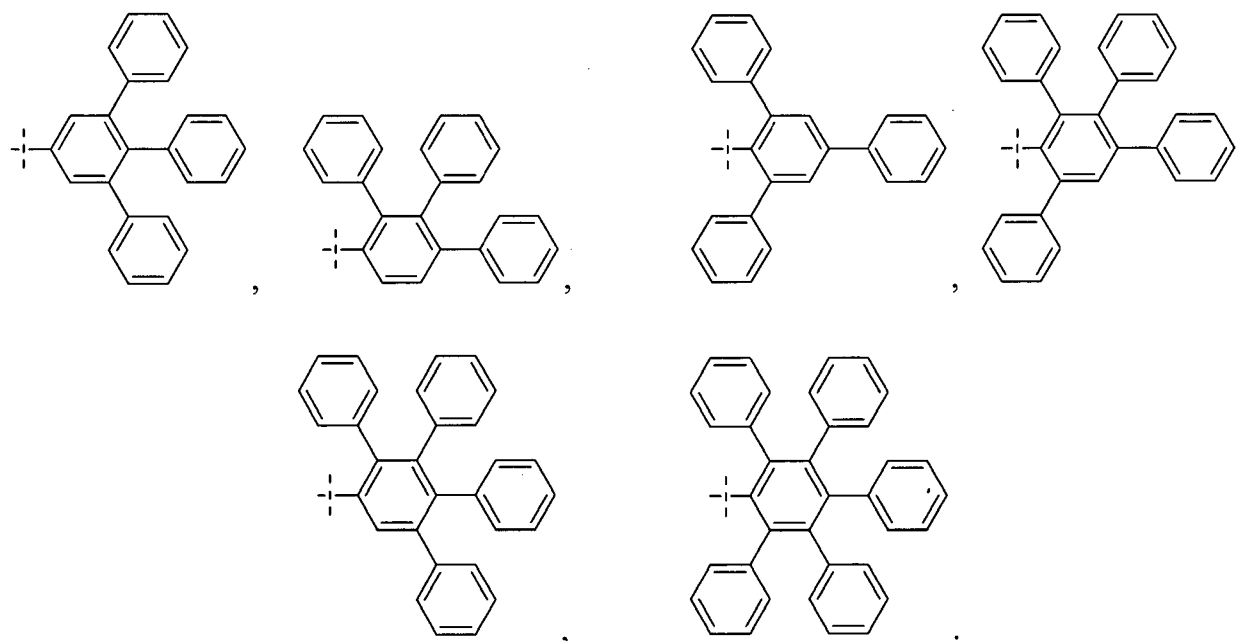
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[0008] These systems shall be considered as conjugated systems of at least 10 delocalized electrons notwithstanding the fact that it cannot be excluded that the phenyl moieties may be twisted against each other resulting in lowered conjugation of the system. That is, the "conjugated system" in the Ar^2 moiety (formed by condensed aromatics or aromatics conducted with each other only by single bonds) is free from sp^3 -hybridised carbon atoms. sp^3 -hybridised carbon atoms may, however, be present in the substituents on Ar^2 , for example in form of alkyl substituents.

[0009] The term "alkyl" as used herein shall encompass linear as well as branched and cyclic alkyl. For example, C_3 -alkyl may be selected from n-propyl and iso-propyl. Likewise, C_4 -alkyl encompasses n-butyl, sec-butyl and t-butyl. Likewise, C_6 -alkyl encompasses n-hexyl and cyclohexyl.

[0010] The subscripted number n in C_n relates to the total number of carbon atoms in the respective alkyl, arylene, heteroarylene or aryl group.

[0011] The term "aryl" as used herein shall encompass phenyl (C_6 -aryl), fused aromatics, such as naphthalene, anthracene, phenanthracene, tetracene etc. Further encompassed are biphenyl and oligo- or polyphenyls, such as terphenyl etc. Further encompassed shall be any further aromatic hydrocarbon substituents, such as fluorenyl etc. Arylene, respectively heteroarylene refers to groups to which two further moieties are attached.

[0012] The term "heteroaryl" as used herein refers to aryl groups in which at least one carbon atom is substituted by a heteroatom, preferably selected from N, O, S, B or Si.

[0013] The subscripted number n in C_n -heteroaryl merely refers to the number of carbon atoms excluding the number of heteroatoms. In this context, it is clear that a C_3 heteroarylene group is an aromatic compound comprising three carbon atoms, such as pyrazol, imidazole, oxazole, thiazole and the like.

[0014] In a preferred embodiment, Ar^2 is selected from C_8 to C_{40} heteroarylene groups which comprise at least one oxygen or at least one nitrogen atom or at least one sulfur atom. Preferably, the C_8 to C_{40} heteroarylene group comprises one nitrogen or one oxygen atom.

[0015] In case of Ar^1 , Ar^2 and Ar^3 being substituted, the groups may comprise one or more substituents.

[0016] It may be further preferred that R^1 and R^2 are selected the same. That is, it may be preferred that R^1 and R^2 are the same C_1 to C_{16} alkyl group. In case that R^1 and R^2 are selected the same, synthesis of the inventive compounds is simplified.

[0017] In a further preferred embodiment, R^1 and R^2 are each independently selected from C_1 to C_{10} alkyl, preferably C_1 to C_8 alkyl, more preferably C_1 to C_6 alkyl, further preferred C_1 to C_4 alkyl. The selection of a shorter alkyl chain (i.e. a chain having less carbon atoms) is advantageous to adjust the physical and chemical properties, such as evaporation temperature and solubility, of the inventive compounds. C_1 to C_4 alkyl chains are preferred for thermal vacuum deposition processes while C_4 to C_{12} alkyl chains are preferred for processing from solution.

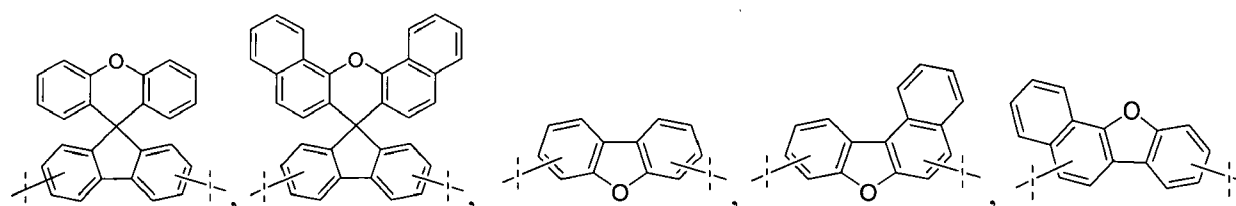
[0018] It may further be preferred that Ar¹ is selected from a group consisting of phenylene, biphenylene, naphthylene, fluorenylene, pyridylene, quinolinyne and pyrimidinylene.

[0019] In this regard, it is further preferred that Ar¹ is selected from C₆ to C₁₄ arylene.

[0020] Better performance with respect to the electronic properties of the inventive layer was achieved when using the preferred Ar¹ groups discussed above.

[0021] In this regard, it is further preferred that n is 1. Compounds comprising an Ar¹ group (n = 1) are found to be superior over compounds not comprising an Ar¹ group (i.e. compounds with n being 0) with respect to the relevant electronic properties.

[0022] Likewise, several specific Ar² groups were found for achieving extraordinary good electronic performance. In particular, it is preferred in this regard that Ar² is selected from a group consisting of naphthylene, fluorenylene, anthracenylene, pyrenylene, phenanthrylene, carbazoylene, benzo[c]acridinylene, dibenzo[c,h]acridinylene, dibenzo[a,j]acridinylene or from a group of the following formulas (IVa) to (IVm),



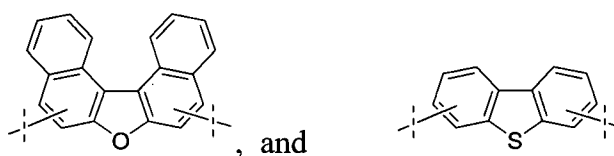
(IVa)

(IVb)

(IVc)

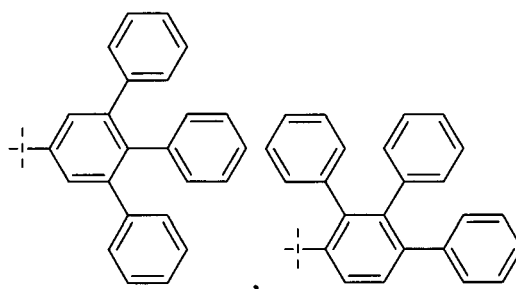
(IVd)

(IVe)



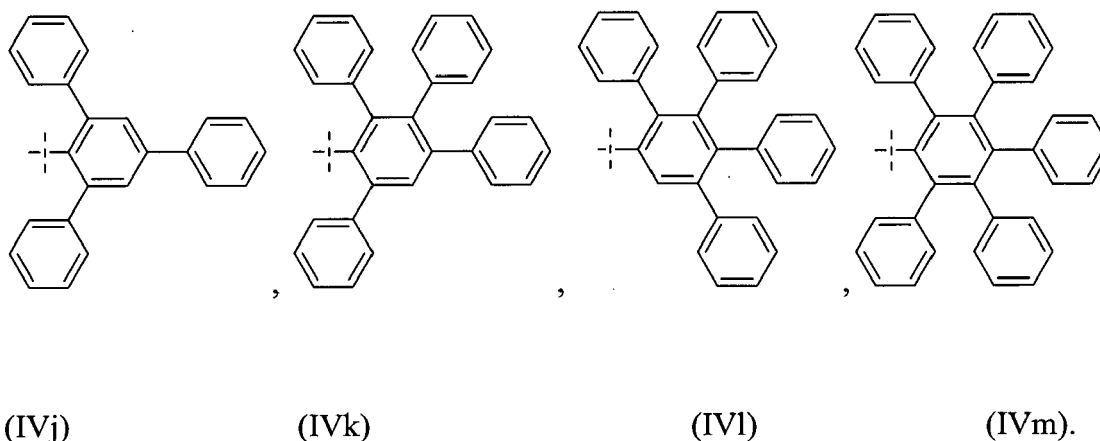
(IVf)

(IVg)

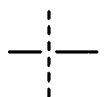


(IVh)

(IVi)



[0023] The positions by which the respective Ar^2 groups of formulas (IVa) to (IVm) are linked to the R^3 group, on the one hand, and the Ar^1 or the P atom, respectively, on the other hand, are marked in the above structure by the symbol of a chemical bond crossed by a dashed line



The connections can be made at any position of the respective aromatic ring marked this way.

[0024] In a preferred embodiment, Ar^2 is selected from a group consisting of anthracenylene, pyrenylene, phenanthrylene, benzo[c]acridinylene, dibenzo[c,h]acridinylene and dibenzo [a,j]acridinylene.

[0025] It is further particularly preferred that Ar^2 is selected from C_{14} to C_{40} arylene, preferably, C_{14} to C_{22} arylene.

[0026] Several groups from which R^3 may be selected are found to be particularly advantageous with respect to the electronic properties of the inventive compounds in the inventive layers. In this regard, it is preferred that R^3 is selected from H, phenyl, biphenyl, terphenyl, fluorenyl, naphthyl, phenanthryl, pyrenyl, carbazoyl, dibenzofuranyl or dinaphthofuranyl, preferably from H, phenyl, biphenyl or naphthyl.

[0027] Best performance is achieved by combining the above preferred Ar^1 , Ar^2 and R^3 groups.

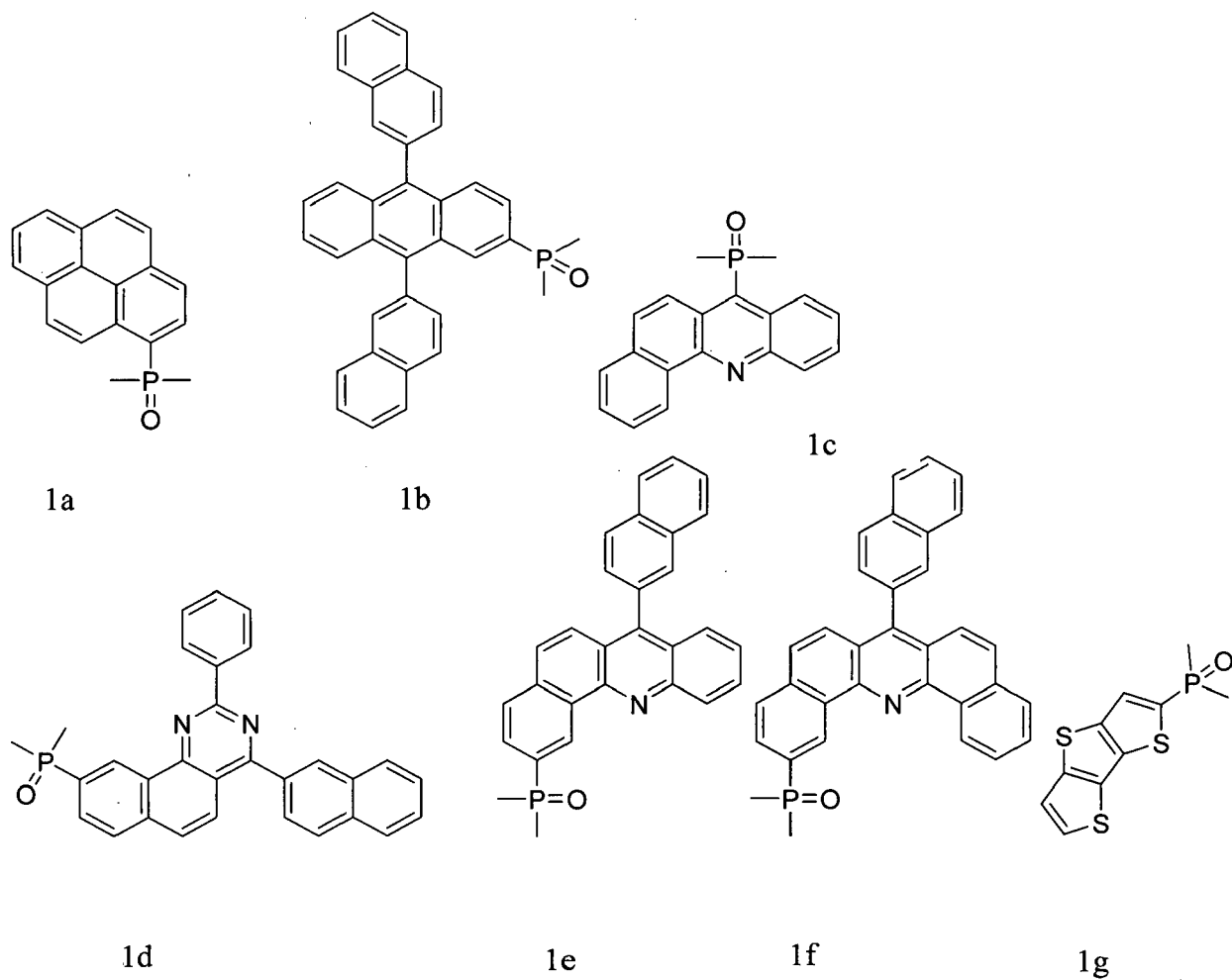
[0028] It may further be preferred that Ar^1 , Ar^2 and R^3 are each independently unsubstituted or substituted with at least one C_1 to C_6 alkyl group, preferably C_1 to C_4 alkyl group.

[0029] It may likewise be preferred that Ar^1 , Ar^2 and R^3 are unsubstituted.

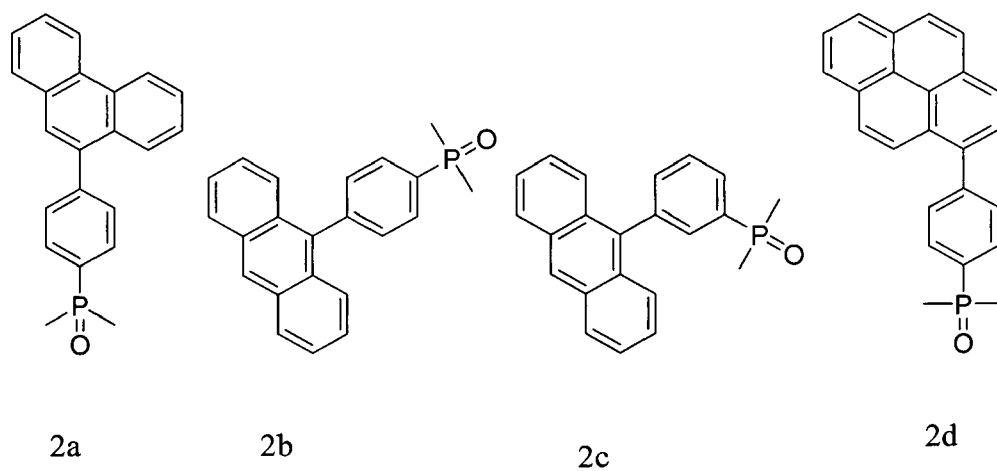
[0030] By attaching substituents to the Ar^1 , Ar^2 and R^3 groups, chemical and physical properties, such as solubility of the respective compounds, may be adjusted. C_1 to C_4 alkyl chains are preferred for thermal vacuum deposition processes while C_4 to C_{12} alkyl chains are preferred for processing from solution.

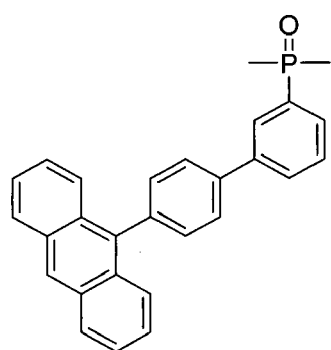
[0031] For vacuum deposition, it may be preferred that Ar^1 , Ar^2 and R^3 groups are unsubstituted.

[0032] In an embodiment, n is 0 and m is 1. Preferred compound of formula (1) in the organic semiconductive layer according to the invention is selected from one of the following compounds 1a to 1g.

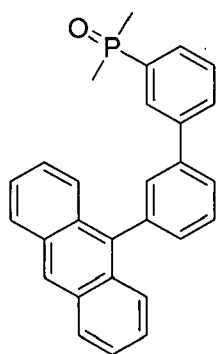


35 **[0033]** In a further embodiment, n is 1 and m is 1 and R³ is H. Preferred compound of formula (1) in the organic semiconductive layer according to the invention is selected from one of the following compounds 2a to 2v.

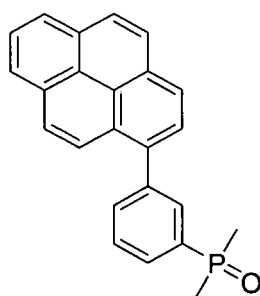




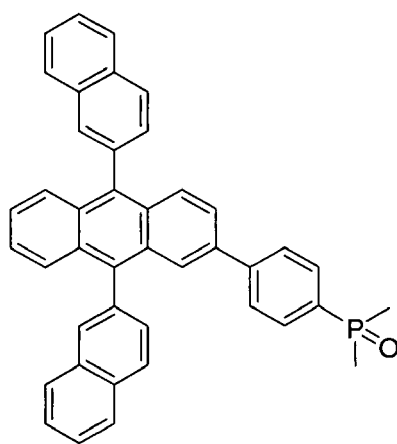
2e



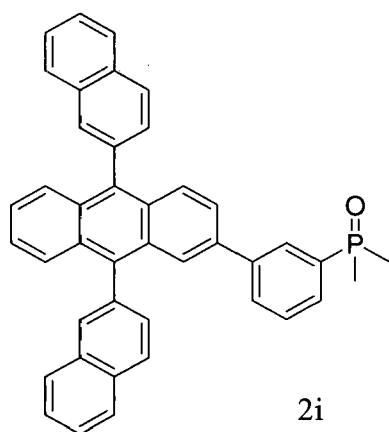
2f



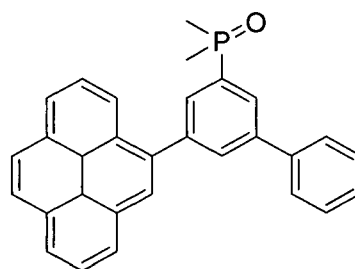
2g



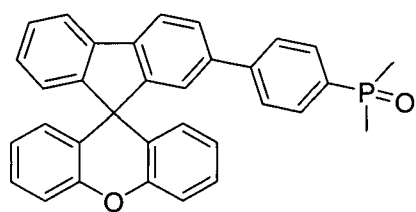
2h



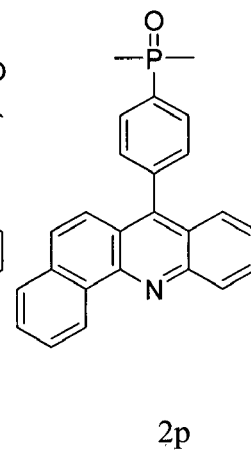
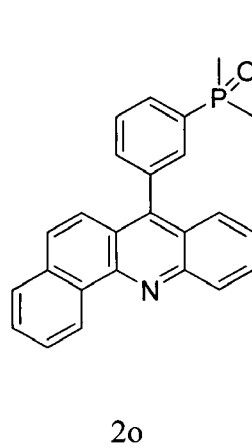
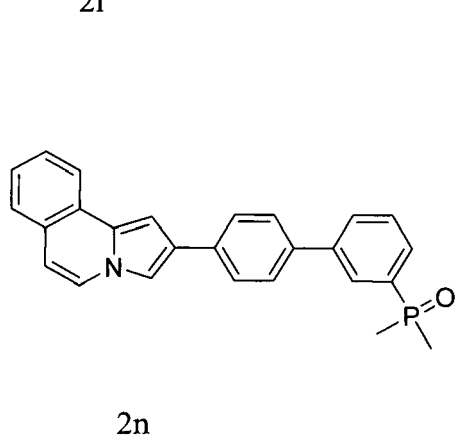
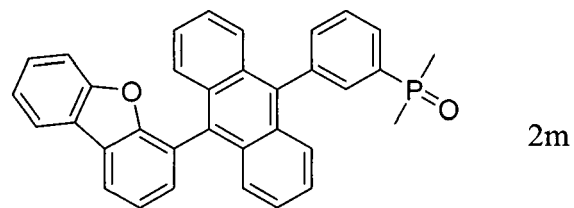
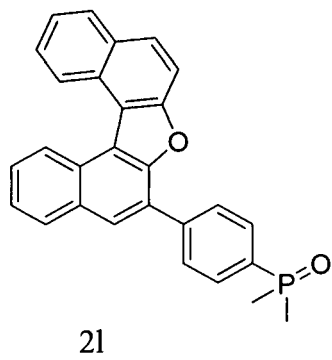
2i

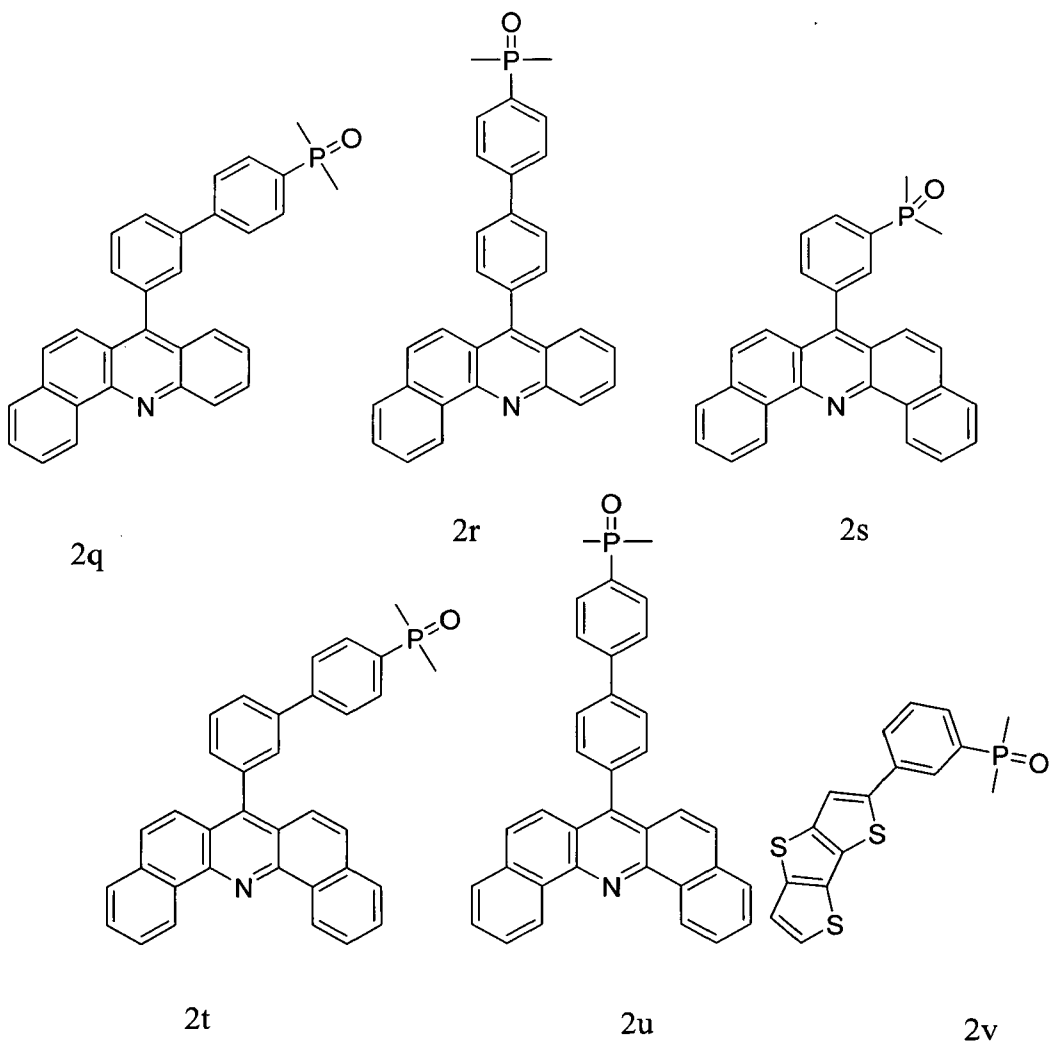


2j

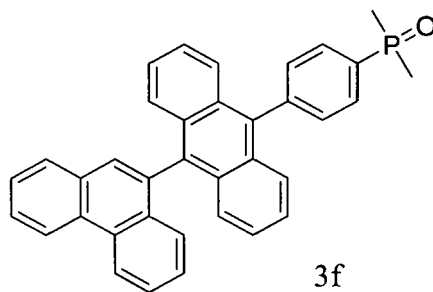
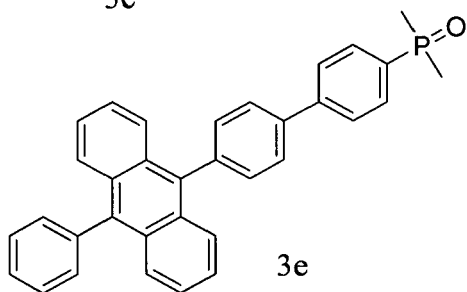
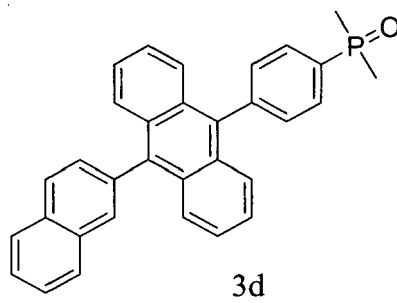
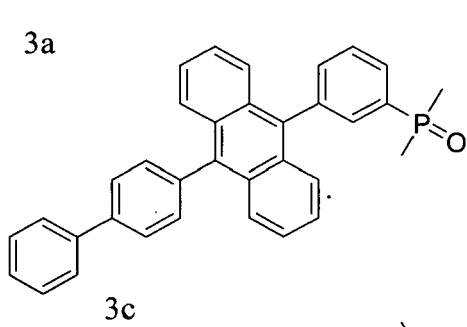
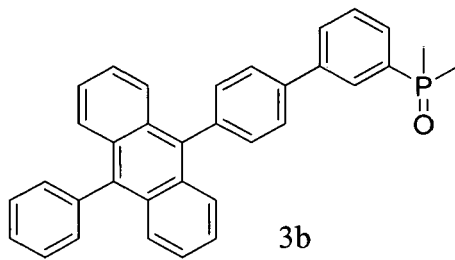
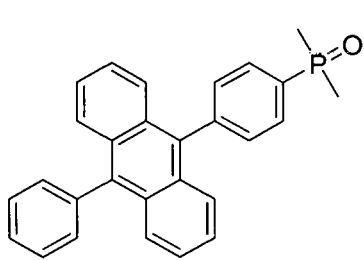


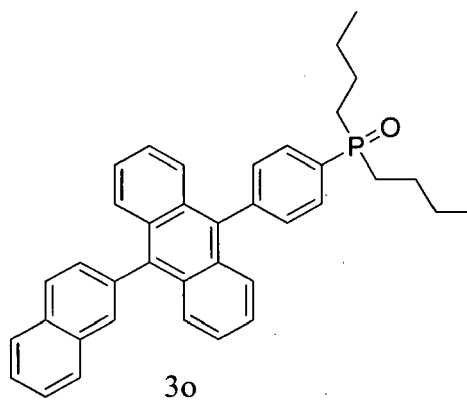
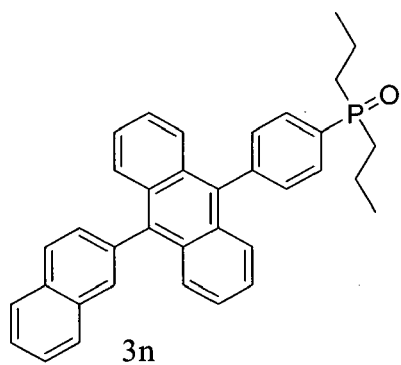
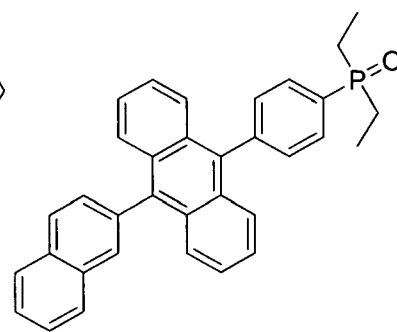
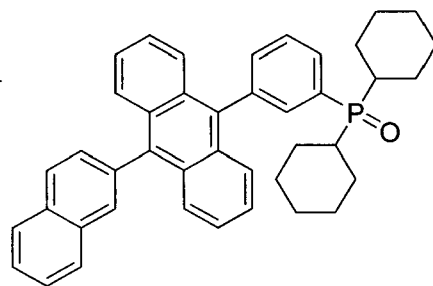
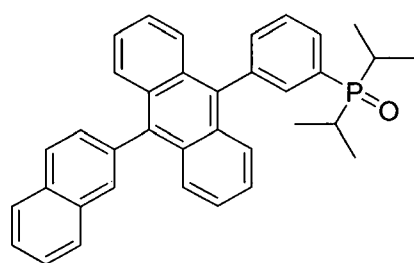
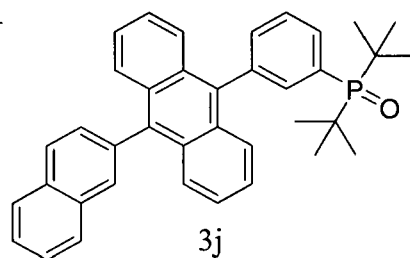
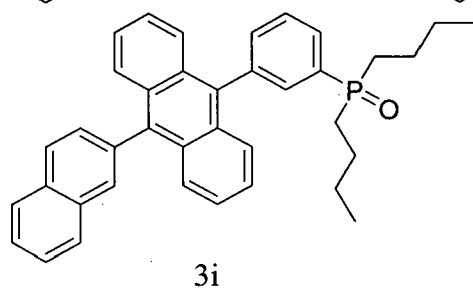
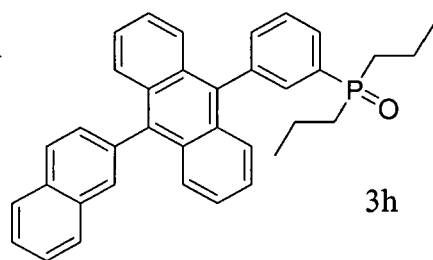
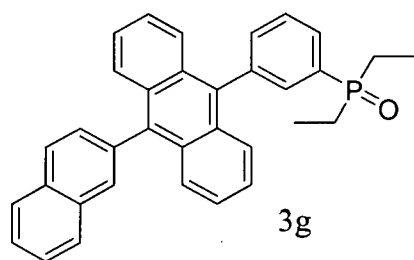
2k





[0034] In a further embodiment, n is 1 and m is 1 and R³ is C₁ to C₁₂ alkyl or C₁₀ to C₂₀ aryl. Preferred compound of formula (1) in the organic semi conductive layer according to the invention is selected from one of the following compounds 3a to 3r.





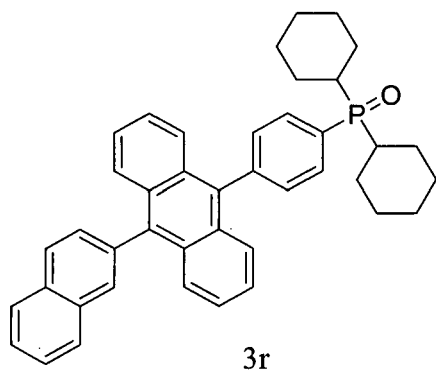
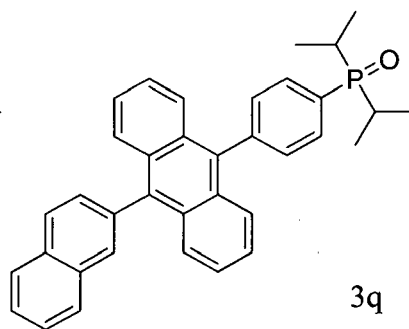
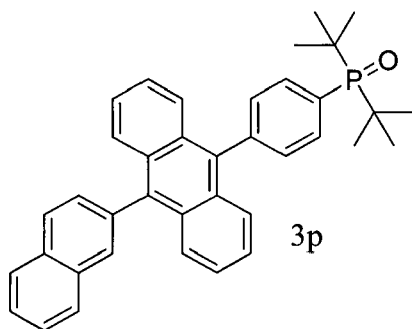
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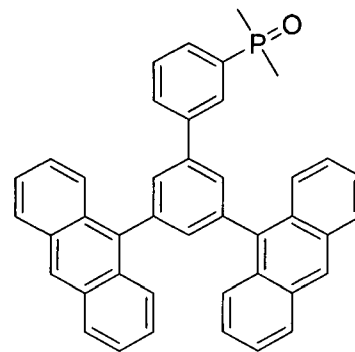
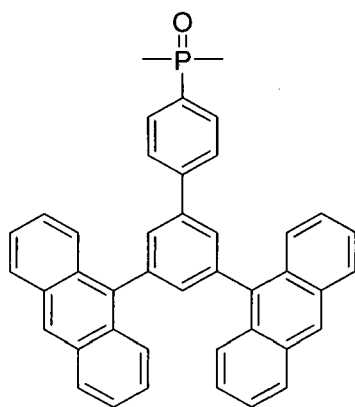
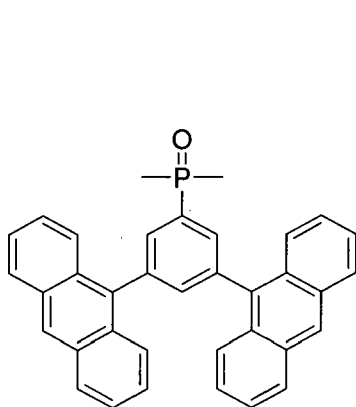
[0035] In a further embodiment, n is 1 and m is 2. Preferred compound of formula (1) in the organic semiconductive layer according to the invention is selected from one of the following compounds 4a to 4f.

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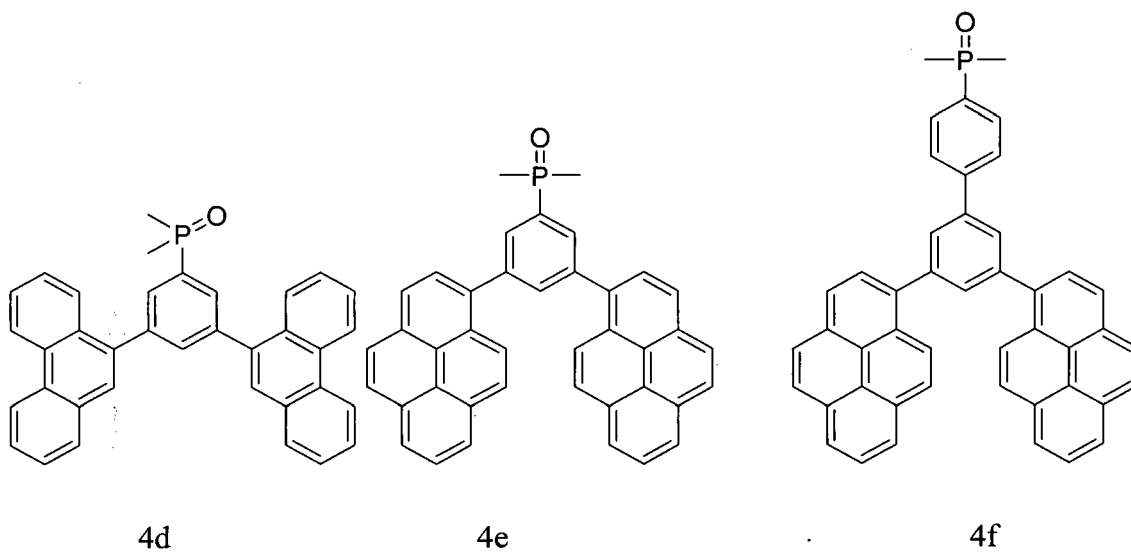
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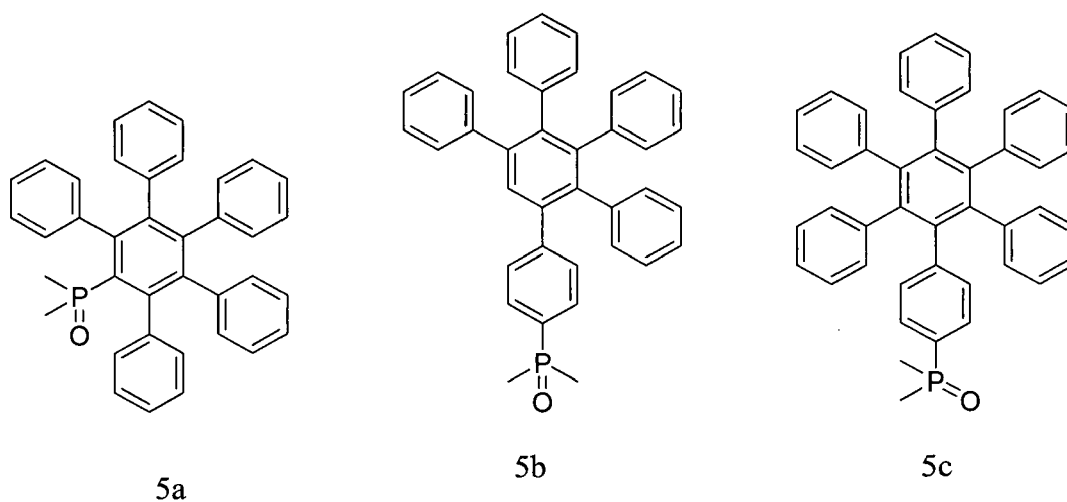


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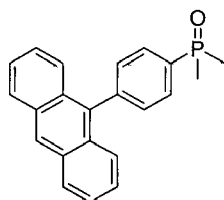
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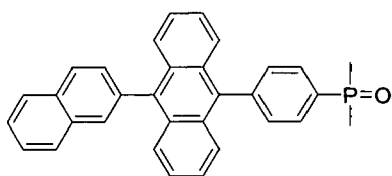
[0036] In a further embodiment, Ar² is selected from particularly bulky substituents. Bulky substituents of the type shown below have a rigid three-dimensional structure which has been found to be particularly preferable. Preferred compound of formula (1) in the organic semiconductive layer according to the invention is selected from one of the following compounds 5a to 5c.



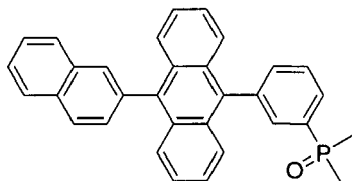
[0037] In extraordinary preferred embodiments, the compound of formula (1) in the organic semiconductive layer according to the invention is selected from one of the following compounds a to g.



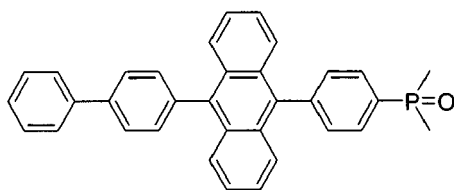
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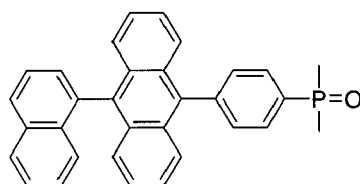
(b)



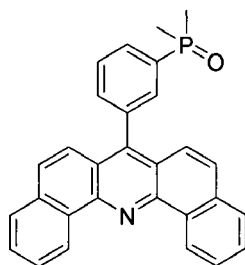
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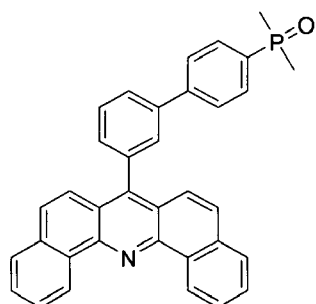
(d)



(e)



(f)



(g).

[0038] By selecting the compound of formula (1) from at least one of the above compounds (a) to (g) best performance of the inventive layers was observed.

[0039] Depending on the intended purpose, the inventive organic semiconductive layer may be doped. In a preferred embodiment, the organic semiconductive layer is doped, preferably electrically doped. Best results were achieved by the following groups of dopants.

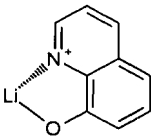
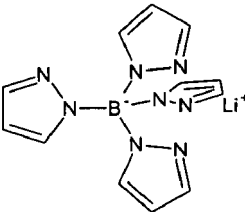
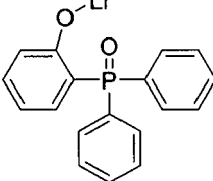
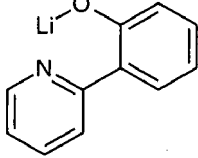
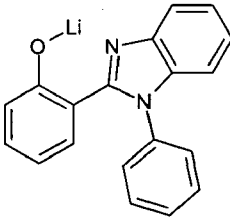
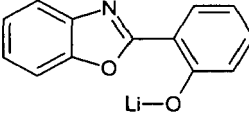
[0040] In this regard, it is preferred that the organic semiconductive layer comprises alkali organic complex and/or an alkali halide.

[0041] Preferably, the alkali organic complex and/or alkali halide are a lithium organic complex and/or lithium halide.

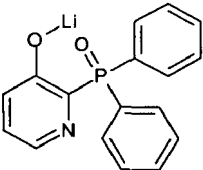
[0042] Suitable organic ligands to form a lithium organic complex that can be used for the electron transport layer are disclosed, for example, in US 2014/0048792 and Kathirgamanathan, Poopathy; Arkley, Vincent; Surendrakumar, Sivagnanasundram; Chan, Yun F.; Ravichandran, Seenivasagam; Ganeshamurugan, Subramaniam; Kumaravel, Muttulingam; Antipan-Lara, Juan; Paramaswara, Gnanamolly; Reddy, Vanga R., Digest of Technical Papers - Society for Information Display International Symposium (2010), 41(Bk. 1), 465-468.

[0043] Particularly preferred lithium organic complexes are shown in Table 1.

Table 1

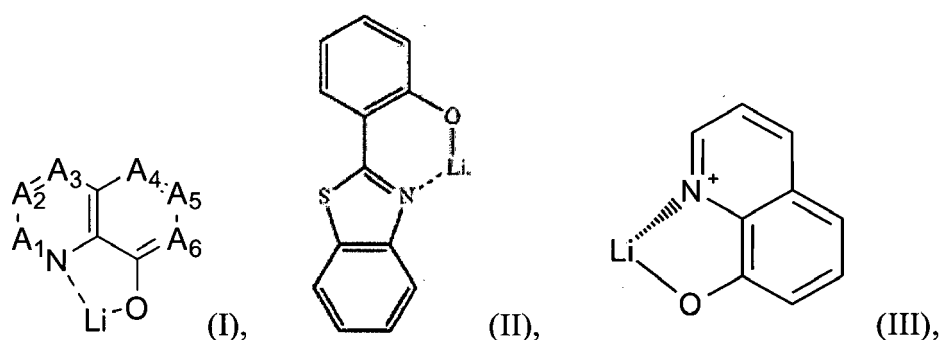
Lithium organic complex that can be suitable used in the organic semiconductive layer			
Compound	Name	Structure	Publication
LiQ	lithium 8-hydroxyquinolate		WO 2013079217 A1
Li-1	lithium tetra(1H-pyrazol-1-yl)borate		WO 2013079676 A1
Li-2	lithium 2-(diphenylphosphoryl)phenolate		WO 2013079678A1
Li-3	lithium 2-(pyridin-2-yl)phenolate		JP 2008195623
Li-4	lithium 2-(1-phenyl-1H-benzo[d]imidazol-2-yl)phenolate		JP 2001291593,
Li-5	lithium 2-(benzo[d]oxazol-2-yl)phenolate		US 20030165711

(continued)

Lithium organic complex that can be suitable used in the organic semiconductive layer			
Compound	Name	Structure	Publication
Li-6	lithium 2-(diphenylphosphoryl)pyridin-3-olate		EP 2724388

[0044] The organic ligand of the lithium organic complex of the organic semiconductive layer may be selected from the group comprising a quinolate, a borate, a phenolate, a pyridinolate or a Schiff base ligand, or Table 1;

- preferably the lithium quinolate complex has the formula I, II, or III:

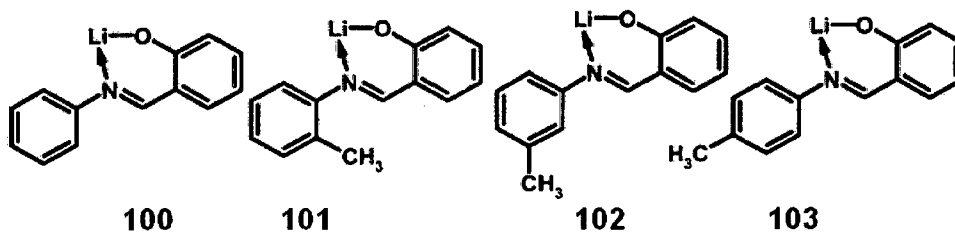


wherein

A₁ to A₆ are same or independently selected from CH, CR, N, O;

R is same or independently selected from hydrogen, halogen, alkyl or aryl or heteroaryl with 1 to 20 carbon atoms; and more preferred A₁ to A₆ are CH;

- preferably the borate based organic ligand is a tetra(1H-pyrazol-1-yl)borate;
- preferably the phenolate is a 2-(pyridin-2-yl)phenolate or a 2-(diphenylphosphoryl)phenolate;
- preferably the lithium Schiff base has the structure 100, 101, 102 or 103:



- more preferred the lithium organic complex is selected from a compound of Table 1.

[0045] The lithium halide of the organic semiconductive layer may be selected from the group comprising a LiF, LiCl, LiBr or LiI, and preferably LiF.

[0046] When the organic semiconductive layer comprising a compound of formula (1) is an electron transport layer or electron injection layer and further comprises a dopant selected from a lithium organic complex and/or of a lithium

halide, particularly low operating voltage and high efficiency and lifetime are obtained.

[0047] It is also preferred that the organic semiconductive layer comprises a zero-valent metal dopant.

[0048] The zero-valent metal dopant is selected from alkali metals, alkaline earth metals, rare earth metals and/or group 3 transition metals. Preferably, the zero-valent metal dopant is selected from the group consisting of Li, Na, K, Rb, Cs, Mg, Ca, Sr, Ba, Yb, Sm, Eu, Nd, Tb, Gd, Ce, La, Sc and Y, more preferred the zero-valent metal dopant is selected from the group consisting of Li, Na, Mg, Ca, Ba, Yb, and even more preferred the zero-valent metal dopant is selected from the group consisting of Li, Mg, Ba, Yb.

[0049] When the organic semiconductive layer comprising a compound of formula (1) is an electron injection layer and/or n-type charge generation layer and further comprises a dopant selected from a zero-valent metal dopant, particularly low operating voltage and high efficiency and lifetime are obtained. For alternative purposes, it may be preferred that the organic semiconductive layer is free of a dopant and consists of the at least one compound of formula (1). This is particularly true, if no dopant is necessary to be present in the inventive layer for operating the same. In particular, the semiconductive organic layer may be free of an alkali organic complex and/or halide and/or zero-valent metal.

[0050] In an embodiment, the organic semiconductive layer is located between the anode and the cathode. Preferably, the layer is located closer to the cathode than to the anode. Preferably, the layer is adjacent to the cathode. Also preferred, the organic semiconductive layer is arranged between the emission layer and the cathode. If a hole blocking layer is present, the organic semiconductive layer is arranged between the hole blocking layer and the cathode.

[0051] In an embodiment, the organic semiconductive layer is an electron transport layer. Preferably, the layer is adjacent to a cathode or an electron injection layer, if present. In another aspect, the organic semiconductive layer is the electron transport layer and the layer is arranged adjacent to a charge generation layer.

[0052] In another embodiment, the organic semiconductive layer is an electron injection layer. Preferably, the layer is arranged between a cathode and an electron transport layer.

[0053] More preferred, the organic semiconductive layer is an electron transport layer and/or an electron injection layer.

[0054] In an embodiment, the organic semiconductive layer is an n-type charge generation layer (CGL). The n-type CGL is arranged between the anode and cathode. If at least one emission layer is present, the n-type CGL is arranged between the first and second emission layer. Preferably, the n-type CGL is adjacent to an emission layer and/or p-type CGL. More preferred, the n-type CGL is arranged between an emission layer and a p-type CGL.

[0055] In another aspect, the organic semiconductive layer is not an anode layer or a cathode layer. If not discussed otherwise, the terms anode (cathode), anode (cathode) layer and anode (cathode) electrode are used synonymously herein.

[0056] In another aspect, the organic semiconductive layer is not an emission layer. Preferably, the organic semiconductive layer is free of emitter.

[0057] In a preferred embodiment, the organic semiconductive layer is in direct contact with the emission layer.

[0058] In another aspect, the organic semiconductive layer is in direct contact with the cathode.

[0059] In another aspect, the organic semiconductive layer is arranged between the emission layer and an electron injection layer and is in direct contact with both layers.

[0060] In another aspect, the organic semiconductive layer is arranged between the emission layer and an n-type CGL and is in direct contact with both layers. In another aspect, the organic semiconductive layer is arranged between an electron transport layer and a p-type CGL and is in direct contact with both layers.

[0061] In another aspect, the organic semiconductive layer is arranged between the emission layer and a p-type CGL and is in direct contact with both layers.

[0062] In another aspect, the organic semiconductive layer is arranged between the emission layer and the cathode layer and is in direct contact with both layers.

[0063] In another aspect, the organic semiconductive layer is arranged between an electron transport layer and the cathode layer and is in direct contact with both layers.

[0064] The object is further achieved by an organic electroluminescent device (OLED) comprising the inventive organic semiconductive layer.

[0065] The organic electroluminescent device (OLED) may be a bottom- or top-emission device.

[0066] According to another aspect, the organic electroluminescent device according to the present invention may comprise more than one emission layer, preferably two or three emission layers. An OLED comprising more than one emission layer is also described as a tandem OLED or stacked OLED.

[0067] Another aspect is directed to a device comprising at least one organic electroluminescent device (OLED). A device comprising organic light-emitting diodes is for example a display or a lighting panel.

[0068] In the present invention, the following defined terms, these definitions shall be applied, unless a different definition is given in the claims or elsewhere in this specification.

[0069] In the context of the present specification the term "different" or "differs" in connection with the matrix material means that the matrix material differs in their structural formula.

[0070] In the context of the present specification the term "different" or "differs" in connection with the lithium compound

means that the lithium compound differs in their structural formula.

[0071] The external quantum efficiency, also named EQE, is measured in percent (%).

[0072] The lifetime, also named LT, between starting brightness and 97 % of the original brightness is measured in hours (h).

[0073] The operating voltage, also named V, is measured in Volt (V) at 10 milliAmpere per square centimeter (mA/cm²) in bottom emission devices and at 15 mA/cm² in top emission devices.

[0074] The color space is described by coordinates CIE-x and CIE-y (International Commission on Illumination 1931). For blue emission the CIE-y is of particular importance. A smaller CIE-y denotes a deeper blue color.

[0075] The highest occupied molecular orbital, also named HOMO, and lowest unoccupied molecular orbital, also named LUMO, are measured in electron volt (eV).

[0076] The terms "OLED" and "organic electroluminescent device" and "organic light-emitting diode" are simultaneously used and have the same meaning.

[0077] The term "electron transport layer stack" as used in the specification comprises at least two electron transport layers or at least three electron transport layers.

[0078] The term "different compound" as used in connection with the matrix compound means that the matrix compound differs from the other matrix compound in its chemical formula.

[0079] As used herein, "weight percent", "wt.-%", "percent by weight", "% by weight", and variations thereof refer to a composition, component, substance or agent as the weight of that component, substance or agent of the respective electron transport layer divided by the total weight of the respective electron transport layer thereof and multiplied by 100. It is understood that the total weight percent amount of all components, substances and agents of the respective electron transport layer and electron injection layer are selected such that it does not exceed 100 wt.-%.

[0080] As used herein, "volume percent", "vol.-%", "percent by volume", "% by volume", and variations thereof refer to a composition, component, substance or agent as the volume of that component, substance or agent of the respective electron transport layer divided by the total volume of the respective electron transport layer thereof and multiplied by 100. It is understood that the total volume percent amount of all components, substances and agents of the cathode layer are selected such that it does not exceed 100 vol.-%.

[0081] All numeric values are herein assumed to be modified by the term "about", whether or not explicitly indicated. As used herein, the term "about" refers to variation in the numerical quantity that can occur. Whether or not modified by the term "about" the claims include equivalents to the quantities.

[0082] It should be noted that, as used in this specification and the appended claims, the singular forms "a", "an", and "the" include plural referents unless the content clearly dictates otherwise.

[0083] The term "free of", "does not contain", "does not comprise" does not exclude impurities. Impurities have no technical effect with respect to the object achieved by the present invention.

[0084] In the context that the electron transport layer is free of a zero-valent metal dopant, alkali halide, alkali organic complex and/or emitter, the term "free of" means that the so called "free of" electron transport layer may comprise of about 5 wt.-% or less of a zero-valent metal dopant, alkali halide, alkali organic complex and/or emitter, preferably about 0.5 wt.-% or less, and more preferably about 0.05 wt.-% or less, and even more preferably about 0.005 wt.-% or less of a zero-valent metal dopant, alkali halide, alkali organic complex and/or emitter and most preferred is free of a zero-valent metal dopant, alkali halide, alkali organic complex and/or emitter.

Substrate

[0085] The substrate may be any substrate that is commonly used in manufacturing of organic light-emitting diodes. If light is emitted through the substrate, the substrate may be a transparent material, for example a glass substrate or a transparent plastic substrate, having excellent mechanical strength, thermal stability, transparency, surface smoothness, ease of handling, and waterproofness. If light is emitted through the top surface, the substrate may be a transparent or non-transparent material, for example a glass substrate, a plastic substrate, a metal substrate or a silicon substrate.

Anode electrode

[0086] The anode electrode may be formed by depositing or sputtering a compound that is used to form the anode electrode. The compound used to form the anode electrode may be a high work-function compound, so as to facilitate hole injection. The anode material may also be selected from a low work function material (i.e. Aluminum). The anode electrode may be a transparent or reflective electrode. Transparent conductive compounds, such as indium tin oxide (ITO), indium zinc oxide (IZO), tin-dioxide (SnO₂), and zinc oxide (ZnO), may be used to form the anode electrode 120. The anode electrode 120 may also be formed using magnesium (Mg), aluminum (Al), aluminum-lithium (Al-Li), calcium (Ca), magnesium-indium (Mg-In), magnesium-silver (Mg-Ag), silver (Ag), gold (Au), or the like.

Hole injection layer

[0087] The hole injection layer (HIL) 130 may be formed on the anode electrode 120 by vacuum deposition, spin coating, printing, casting, slot-die coating, Langmuir-Blodgett (LB) deposition, or the like. When the HIL 130 is formed using vacuum deposition, the deposition conditions may vary according to the compound that is used to form the HIL 130, and the desired structure and thermal properties of the HIL 130. In general, however, conditions for vacuum deposition may include a deposition temperature of 100° C to 500° C, a pressure of 10⁻⁸ to 10⁻³ Torr (1 Torr equals 133.322 Pa), and a deposition rate of 0.1 to 10 nm/sec.

[0088] When the HIL 130 is formed using spin coating, printing, coating conditions may vary according to a compound that is used to form the HIL 130, and the desired structure and thermal properties of the HIL 130. For example, the coating conditions may include a coating speed of about 2000 rpm to about 5000 rpm, and a thermal treatment temperature of about 80° C to about 200° C. Thermal treatment removes a solvent after the coating is performed.

[0089] The HIL 130 may be formed of any compound that is commonly used to form an HIL. Examples of compounds that may be used to form the HIL 130 include a phthalocyanine compound, such as copper phthalocyanine (CuPc), 4,4',4"-tris (3-methylphenylphenylamino) triphenylamine (m-MTDATA), TDATA, 2T-NATA, polyaniline/dodecylbenzenesulfonic acid (Pani/DBSA), poly(3,4-ethylenedioxythiophene)/poly(4-styrenesulfonate) (PEDOT/PSS), polyaniline/camphor sulfonic acid (Pani/CSA), and polyaniline/poly(4-styrenesulfonate) (PANI/PSS).

[0090] The HIL 130 may be a pure layer of p-dopant or may be selected from a hole-transporting matrix compound doped with a p-dopant. Typical examples of known redox doped hole transport materials are: copper phthalocyanine (CuPc), which HOMO level is approximately -5.2 eV, doped with tetrafluoro-tetracyanoquinodimethane (F4TCNQ), which LUMO level is about -5.2 eV; zinc phthalocyanine (ZnPc) (HOMO = -5.2 eV) doped with F4TCNQ; α -NPD (N,N'-Bis(naphthalen-1-yl)-N,N'-bis(phenyl)-benzidine) doped with F4TCNQ. α -NPD doped with 2,2'-(perfluoronaphthalen-2,6-diylidene) dimalononitrile (PD1). α -NPD doped with 2,2',2"-(cyclopropane-1,2,3-triylidene)tris(2-(p-cyanotetrafluorophenyl)acetonitrile) (PD2). Dopant concentrations can be selected from 1 to 20 wt.-%, more preferably from 3 wt.-% to 10 wt.-%.

[0091] The thickness of the HIL 130 may be in the range of about 1 nm to about 100 nm, and for example, about 1 nm to about 25 nm. When the thickness of the HIL 130 is within this range, the HIL 130 may have excellent hole injecting characteristics, without a substantial increase in driving voltage.

Hole transport layer

[0092] The hole transport layer (HTL) 140 may be formed on the HIL 130 by vacuum deposition, spin coating, slot-die coating, printing, casting, Langmuir-Blodgett (LB) deposition, or the like. When the HTL 140 is formed by vacuum deposition or spin coating, the conditions for deposition and coating may be similar to those for the formation of the HIL 130. However, the conditions for the vacuum or solution deposition may vary, according to the compound that is used to form the HTL 140.

[0093] The HTL 140 may be formed of any compound that is commonly used to form a HTL. Compound that can be suitably used is disclosed for example in Yasuhiko Shirota and Hiroshi Kageyama, Chem. Rev. 2007, 107, 953-1010 and incorporated by reference. Examples of the compound that may be used to form the HTL 140 are: a carbazole derivative, such as N-phenylcarbazole or polyvinylcarbazole; an amine derivative having an aromatic condensation ring, such as N,N'-bis(3-methylphenyl)-N,N'-diphenyl-[1,1'-biphenyl]-4,4'-diamine (TPD), or N,N'-di(naphthalen-1-yl)-N,N'-diphenyl benzydine (α -NPD); and a triphenylamine-based compound, such as 4,4',4"-tris(N-carbazolyl)triphenylamine (TCTA). Among these compounds, TCTA can transport holes and inhibit excitons from being diffused into the EML.

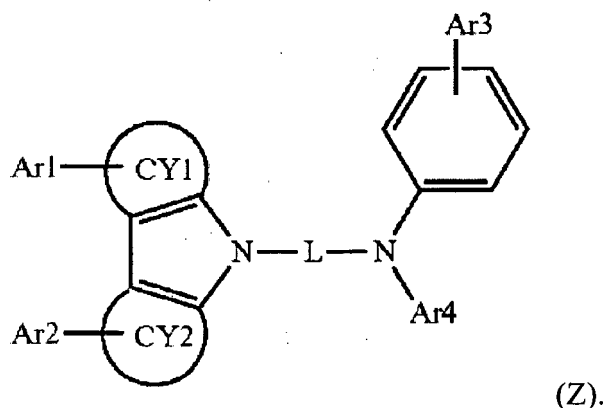
[0094] The thickness of the HTL 140 may be in the range of about 5 nm to about 250 nm, preferably, about 10 nm to about 200 nm, further about 20 nm to about 190 nm, further about 40 nm to about 180 nm, further about 60 nm to about 170 nm, further about 80 nm to about 160 nm, further about 100 nm to about 160 nm; further about 120 nm to about 140 nm. A preferred thickness of the HTL 140 may be 170 nm to 200 nm.

[0095] When the thickness of the HTL 140 is within this range, the HTL 140 may have excellent hole transporting characteristics, without a substantial increase in driving voltage.

Electron blocking layer

[0096] The function of the electron blocking layer (EBL) 150 is to prevent electrons from being transferred from the emission layer to the hole transport layer and thereby confine electrons to the emission layer. Thereby, efficiency, operating voltage and/or lifetime are improved. Typically, the electron blocking layer comprises a triarylamine compound. The triarylamine compound may have a LUMO level closer to vacuum level than the LUMO level of the hole transport layer. The electron blocking layer may have a HOMO level that is further away from vacuum level compared to the

HOMO level of the hole transport layer. The thickness of the electron blocking layer is selected between 2 and 20 nm. The electron blocking layer may comprise a compound of formula Z below



In Formula Z,

CY1 and CY2 are the same as or different from each other, and each independently represent a benzene cycle or a naphthalene cycle,

Ar1 to Ar3 are the same as or different from each other, and each independently selected from the group consisting of hydrogen; a substituted or unsubstituted aryl group having 6 to 30 carbon atoms; and a substituted or unsubstituted heteroaryl group having 5 to 30 carbon atoms,

Ar4 is selected from the group consisting of a substituted or unsubstituted phenyl group, a substituted or unsubstituted biphenyl group, a substituted or unsubstituted terphenyl group, a substituted or unsubstituted triphenylene group, and a substituted or unsubstituted heteroaryl group having 5 to 30 carbon atoms,

L is a substituted or unsubstituted arylene group having 6 to 30 carbon atoms.

[0097] If the electron blocking layer has a high triplet level, it may also be described as triplet control layer.

The function of the triplet control layer is to reduce quenching of triplets if a phosphorescent green or blue emission layer is used. Thereby, higher efficiency of light emission from a phosphorescent emission layer can be achieved. The triplet control layer is selected from triarylamine compounds with a triplet level above the triplet level of the phosphorescent emitter in the adjacent emission layer. Suitable triplet control layer, in particular the triarylamine compounds, are described in EP 2 722 908 A1.

Emission layer (EML)

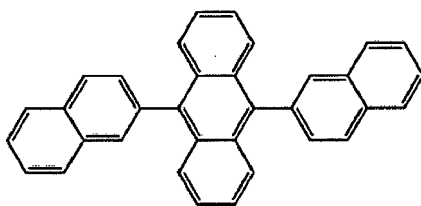
[0098] The EML 150 may be formed on the HTL by vacuum deposition, spin coating, slot-die coating, printing, casting, LB, or the like. When the EML is formed using vacuum deposition or spin coating, the conditions for deposition and coating may be similar to those for the formation of the HIL. However, the conditions for deposition and coating may vary, according to the compound that is used to form the EML.

The emission layer (EML) may be formed of a combination of a host and a dopant. Example of the host are Alq3, 4,4'-N,N'-dicarbazole-biphenyl (CBP), poly(n-vinylcarbazole) (PVK), 9,10-di(naphthalene-2-yl)anthracene (ADN), 4,4',4"-Tris(carbazol-9-yl)-triphenylamine

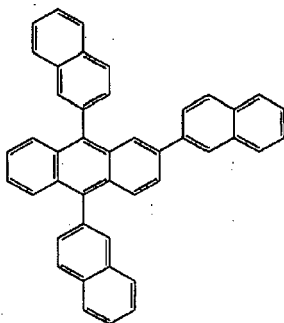
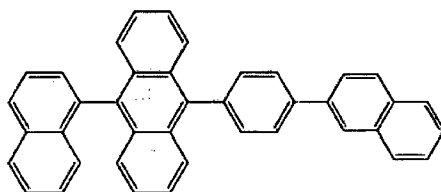
[0099] (TCTA), 1,3,5-tris(N-phenylbenzimidazole-2-yl)benzene (TPBI), 3-tert-butyl-9,10-di-2-naphthylanthracene (TBADN), distyrylarylene (DSA), Bis(2-(2-hydroxyphenyl)benzothiazole)zinc (Zn(BTZ) 2), E3 below, AND, Compound 1 below, and Compound 2 below.



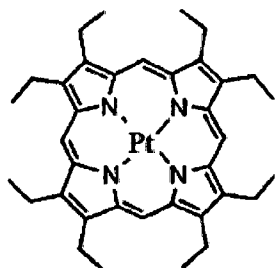
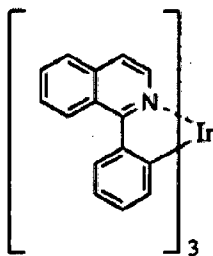
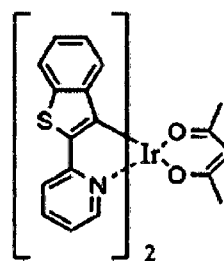
E3



AND

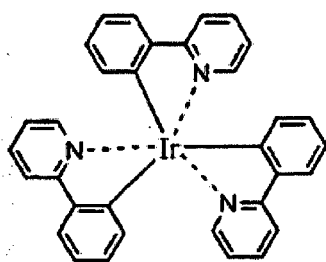
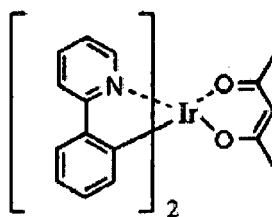
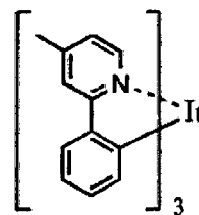
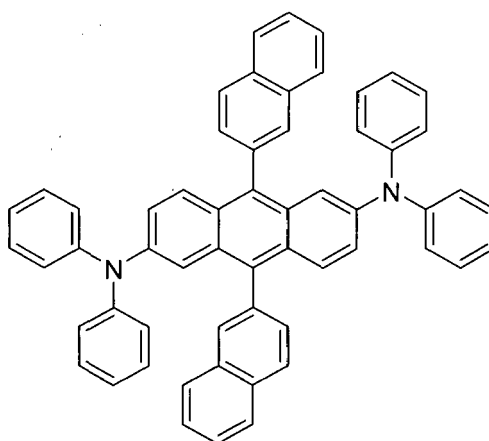
**Compound 1****Compound 2**

[0100] The dopant may be a phosphorescent or fluorescent emitter. Phosphorescent emitters and emitters which emit light via a thermally activated delayed fluorescence (TADF) mechanism are preferred due to their higher efficiency. The emitter may be a small molecule or a polymer. Examples of a red dopant are PtOEP, Ir(piq) 3, and Btp 2Ir(acac), but are not limited thereto. These compounds are phosphorescent emitters, however, fluorescent red dopants could also be used.

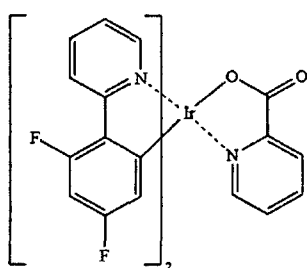
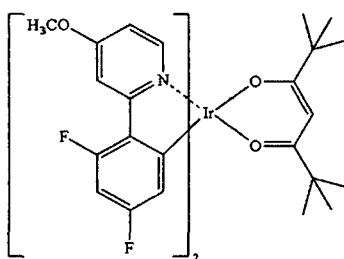
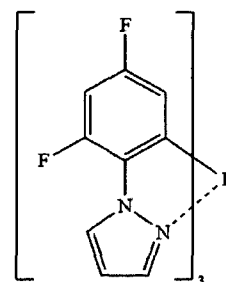
**PtOEP****Ir(piq)₃****Btp₂Ir(acac)**

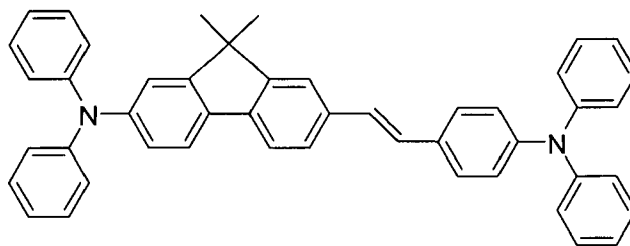
[0101] Examples of a phosphorescent green dopant are Ir(ppy) 3 (ppy = phenylpyridine), Ir(ppy) 2(acac), Ir(mppy) 3

are shown below. Compound 3 is an example of a fluorescent green emitter and the structure is shown below.

**Ir(ppy)₃****Ir(ppy)₂(acac)****Ir(mpyp)₃****Compound 3**

[0102] Examples of a phosphorescent blue dopant are F₂Irpic, (F₂ppy)₂Ir(tmd) and Ir(dfppz)₃, ter-fluorene, the structures are shown below. 4,4'-bis(4-diphenyl amino styryl)biphenyl (DPAVB_i), 2,5,8,11-tetra-tert-butyl perylene (TBPe), and Compound 4 below are examples of fluorescent blue dopants.

**F₂Irpic****(F₂ppy)₂Ir(tmd)****Ir(dfppz)₃**

**Compound 4**

[0103] The amount of the dopant may be in the range of about 0.01 to about 50 parts by weight, based on 100 parts by weight of the host. Alternatively, the emission layer may consist of a light-emitting polymer. The EML may have a thickness of about 10 nm to about 100 nm, for example, about 20 nm to about 60 nm. When the thickness of the EML is within this range, the EML may have excellent light emission, without a substantial increase in driving voltage.

Hole blocking layer (HBL)

[0104] When the EML comprises a phosphorescent dopant, a hole blocking layer (HBL) may be formed on the EML, by using vacuum deposition, spin coating, slot-die coating, printing, casting, LB deposition, or the like, in order to prevent the diffusion of triplet excitons or holes into the ETL.

[0105] When the HBL is formed using vacuum deposition or spin coating, the conditions for deposition and coating may be similar to those for the formation of the HIL. However, the conditions for deposition and coating may vary, according to the compound that is used to form the HBL. Any compound that is commonly used to form a HBL may be used. Examples of compounds for forming the HBL include an oxadiazole derivative, a triazole derivative, and a phenanthroline derivative.

[0106] The HBL may have a thickness of about 5 nm to about 100 nm, for example, about 10 nm to about 30 nm. When the thickness of the HBL is within this range, the HBL may have excellent hole-blocking properties, without a substantial increase in driving voltage.

Compounds used in the electron transport layer (ETL)

[0107] The OLED according to the present invention may not contain an electron transport layer (ETL). However, the OLED according to the present invention may optional contain an electron transport layer (ETL).

[0108] According to various embodiments the OLED may comprises an electron transport layer or an electron transport layer stack comprising at least a first electron transport layer and at least a second electron transport layer.

[0109] According to various embodiments of the OLED of the present invention the electron transport layer may comprises at least one matrix compound. Preferably, the matrix compound is an organic compound. More preferred, the matrix compound is a covalent organic matrix compound. In other words, the matrix compound comprises covalent bonds. It is to be understood that "substantially covalent" means compounds comprising elements bound together mostly by covalent bonds.

[0110] According to various embodiments of the OLED the matrix compound may be selected from:

- an anthracene based compound or a heteroaryl substituted anthracene based compound, preferably 2-(4-(9,10-di(naphthalen-2-yl)anthracene-2-yl)phenyl)-1-phenyl-1H-benzo[d]imidazole and/or N4,N4"-di(naphthalen-1-yl)-N4,N4"-diphenyl-[1,1':4',1"-terphenyl]-4,4"-diamine;
- a phosphine oxide based compound, preferably (3-(dibenzo[c,h]acridin-7-yl)phenyl)diphenylphosphine oxide and/or phenyl bis(3-(pyren-1-yl)phenyl)phosphine oxide and/or 3-Phenyl-3H-benzo[b]dinaphtho[2,1-d:1',2'-f]phosphine-3-oxide; or
- a substituted phenanthroline compound, preferably 2,4,7,9-tetraphenyl-1,10-phenanthroline, 4,7-diphenyl-2,9-di-p-tolyl-1,10-phenanthroline, or 2,9-di(biphenyl-4-yl)-4,7-diphenyl-1,10-phenanthroline.

[0111] According to various embodiments of the OLED the matrix compound of the electron transport layer may be preferably selected from:

- a phosphine oxide based compound, preferably (3-(dibenzo[c,h]acridin-7-yl)phenyl)diphenylphosphine oxide, 3-phenyl-3H-benzo[b]dinaphtho[2,1-d:1',2'-f]phosphine-3-oxide and/or phenyl bis(3-(pyren-1-yl)phenyl)phosphine oxide; or

- a substituted phenanthroline compound, preferably 2,4,7,9-tetraphenyl-1,10-phenanthroline, 4,7-diphenyl-2,9-di-p-tolyl-1,10-phenanthroline, or 2,9-di(biphenyl-4-yl)-4,7-diphenyl-1,10-phenanthroline.

[0112] According to various embodiments of the OLED the matrix compound of the electron transport layer may be more preferred selected from:

- a phosphine oxide based compound, preferably (3-(dibenzo[c,h]acridin-7-yl)phenyl)diphenylphosphine oxide, 3-phenyl-3H-benzo[b]dinaphtho[2,1-d:1',2'-f]phosphine-3-oxide and/or phenyl bis(3-(pyren-1-yl)phenyl)phosphine oxide.

[0113] According to various embodiments of the OLED of the present invention the thicknesses of the electron transport layer may be in the range of about ≥ 0.5 nm to about ≤ 95 nm, preferably of about ≥ 3 nm to about ≤ 80 nm, further preferred of about ≥ 5 nm to about ≤ 60 nm, also preferred of about ≥ 6 nm to about ≤ 40 nm, in addition preferred about ≥ 8 nm to about ≤ 20 nm and more preferred of about ≥ 10 nm to about ≤ 18 nm.

[0114] According to various embodiments of the OLED of the present invention the thicknesses of the electron transport layer stack can be in the range of about ≥ 25 nm to about ≤ 100 nm, preferably of about ≥ 30 nm to about ≤ 80 nm, further preferred of about ≥ 35 nm to about ≤ 60 nm, and more preferred of about ≥ 36 nm to about ≤ 40 nm.

[0115] According to one embodiment of the OLED, the electron transport layer comprises of about ≥ 50 wt.-% to about ≤ 60 wt.-% of a first lithium halide or a first lithium organic complex and about ≤ 50 wt.-% to about ≥ 40 wt.-% of a matrix compound of:

- a phosphine oxide based compound, preferably (3-(dibenzo[c,h]acridin-7-yl)phenyl)diphenylphosphine oxide, 3-phenyl-3H-benzo[b]dinaphtho[2,1-d:1',2'-f]phosphine-3-oxide and/or phenyl bis(3-(pyren-1-yl)phenyl)phosphine oxide; or
- a substituted phenanthroline compound, preferably 2,4,7,9-tetraphenyl-1,10-phenanthroline, 4,7-diphenyl-2,9-di-p-tolyl-1,10-phenanthroline, or 2,9-di(biphenyl-4-yl)-4,7-diphenyl-1,10-phenanthroline.

[0116] The light-emitting diode (OLED) may comprises at least two electrodes, an anode electrode and a cathode electrode.

[0117] The electron transport layer/s or electron transport layer stack is not an electrode. The electron transport layer/s or electron transport layer are sandwiched between two electrodes, namely sandwiched between an anode and a second cathode.

[0118] The ETL may be formed optional on an EML or on the HBL if the HBL is formed. The ETL includes a first layer including a first lithium halide or a first lithium organic complex; and optional a second electron transport layer including a second lithium halide or a second lithium organic complex, wherein optional the first lithium organic complex is not the same as the second lithium organic complex and wherein the first lithium halide is not the same as the second lithium halide.

[0119] The ETL includes a first layer comprising a first matrix compound and a lithium halide or a lithium organic complex; and optional a second electron transport layer comprising a second matrix compound and a metal dopant selected from a group comprising alkali, alkaline earth and rare earth metals.

[0120] The ETL includes a first layer comprising a first matrix compound and a lithium halide or a lithium organic complex; and optional a second electron transport layer comprising a second matrix compound and is free of dopant.

[0121] The ETL may have a stacked structure, preferably of two ETL-layers, so that injection and transport of electrons may be balanced and holes may be efficiently blocked. In a conventional OLED, since the amounts of electrons and holes vary with time, after driving is initiated, the number of excitons generated in an emission area may be reduced. As a result, a carrier balance may not be maintained, so as to reduce the lifetime of the OLED.

[0122] However, in the ETL, the first layer and the second layer may have similar or identical energy levels, so that the carrier balance may be uniformly maintained, while controlling the electron-transfer rate.

[0123] Matrix compound for the electron layer that can be suitable used are selected from the group comprising anthracene compounds, preferably 2-(4-(9,10-di(naphthalen-2-yl)anthracen-2-yl)phenyl)-1-phenyl-1H-benzo[d]imidazole

[0124] Anthracene compounds that can be used as matrix materials are disclosed in US 6878469 B.

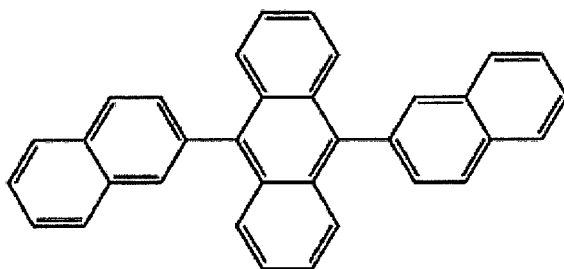
[0125] Other matrix compounds that can be used are diphenylphosphine oxide, preferably (3-(dibenzo[c,h]acridin-7-yl)phenyl)diphenylphosphine oxide, phenylbis(3-(pyren-1-yl)phenyl)phosphine oxide, 3-phenyl-3H-benzo[b]dinaphtho[2,1-d:1',2'-f]phosphine-3-oxide, phenyldi(pyren-1-yl)phosphine oxide.

[0126] Diphenylphosphine oxide compounds that can be used as matrix materials are disclosed in EP 2395571 A1, WO2013079217 A1, EP 13187905, EP13199361 and JP2002063989 A1.

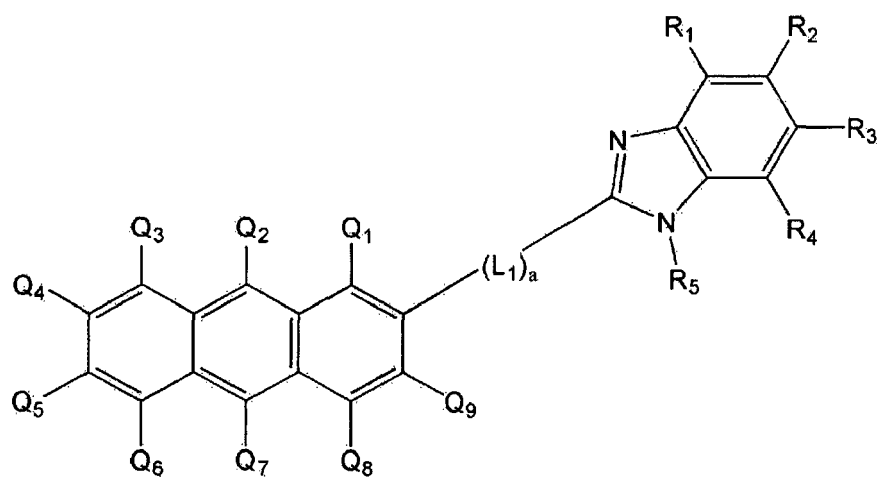
[0127] Other suitable matrix compounds that can be used are phenanthroline compounds, preferably selected from

the group comprising of 2,4,7,9-tetraphenyl-1,10-phenanthroline, 4,7-diphenyl-2,9-di-p-tolyl-1,10-phenanthroline, and 2,9-di(biphenyl-4-yl)-4,7-diphenyl-1,10-phenanthroline. Phenanthroline compounds that can be used as matrix materials are disclosed in EP 1786050 A1.

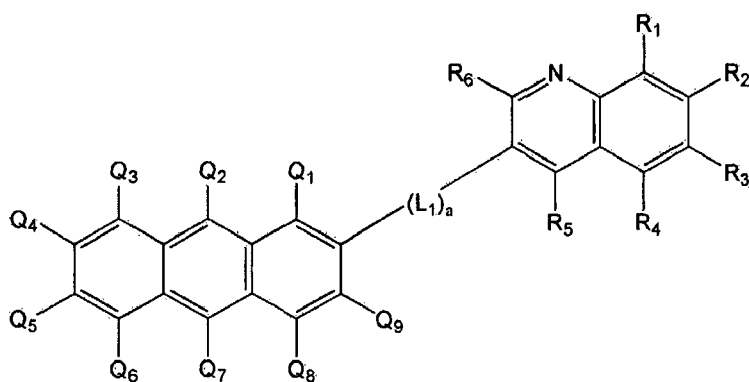
[0128] The matrix compound of the electron transport layer may be a compound that efficiently transports electrons, such as an anthracene-based compound, diphenylphosphine oxide based compound, or a phenanthroline based compound, preferably a matrix compound mentioned in Table 4. For example, the matrix compound of the electron transport layer may be selected from the group consisting of Compound 5, a compound represented by Formula 2, and a compound represented by Formula 3 below:



Compound 5



Formula 2



Formula 3

[0129] In Formulae 2 and 3, R_1 to R_6 are each independently a hydrogen atom, a halogen atom, a hydroxy group, a cyano group, a substituted or unsubstituted C_1 - C_{30} alkyl group, a substituted or unsubstituted C_1 - C_{30} alkoxy group, a substituted or unsubstituted C_1 - C_{30} acyl group, a substituted or unsubstituted C_2 - C_{30} alkenyl group, a substituted or unsubstituted C_2 - C_{30} alkynyl group, a substituted or unsubstituted C_6 - C_{30} aryl group, or a substituted or unsubstituted C_3 - C_{30} heteroaryl group. At least two adjacent R_1 to R_6 groups are optionally bonded to each other, to form a saturated or unsaturated ring. L_1 is a bond, a substituted or unsubstituted C_1 - C_{30} alkylene group, a substituted or unsubstituted C_6 - C_{30} arylene group, or a substituted or unsubstituted C_3 - C_{30} hetero arylene group. Q_1 through Q_9 are each independently a hydrogen atom, a substituted or unsubstituted C_6 - C_{30} aryl group, or a substituted or unsubstituted C_3 - C_{30} hetero aryl group, and "a" is an integer from 1 to 10.

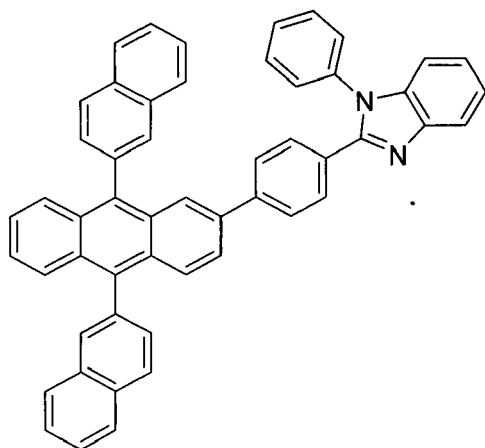
[0130] For example, R_1 to R_6 may be each independently selected from the group consisting of a hydrogen atom, a halogen atom, a hydroxy group, a cyano group, a methyl group, an ethyl group, a propyl group, a butyl group, a methoxy group, an ethoxy group, a propoxy group, a butoxy group, a phenyl group, a naphthyl group, an anthryl group, a pyridinyl group, and a pyrazinyl group.

[0131] In particular, in Formula 2 and/or 3, R_1 to R_4 may each be a hydrogen atom, R_5 may be selected from the group consisting of a halogen atom, a hydroxy group, a cyano group, a methyl group, an ethyl group, a propyl group, a butyl group, a methoxy group, an ethoxy group, a propoxy group, a butoxy group, a phenyl group, a naphthyl group, an anthryl group, a pyridinyl group, and a pyrazinyl group. In addition, in Formula 3, R_1 to R_6 may each be a hydrogen atom.

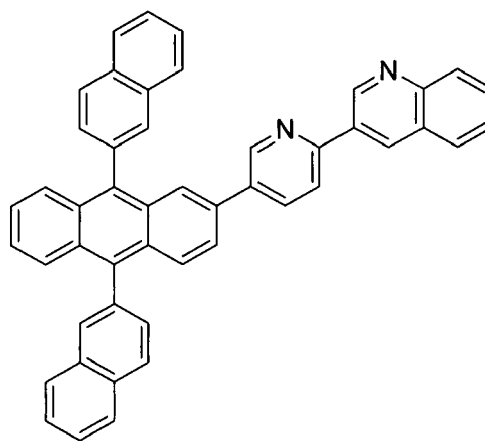
[0132] For example, in Formula 2 and/or 3, Q_1 to Q_9 are each independently a hydrogen atom, a phenyl group, a naphthyl group, an anthryl group, a pyridinyl group, and a pyrazinyl group. In particular, in Formulae 2 and/or 3, Q_1 , Q_3 - Q_6 , Q_8 and Q_9 are hydrogen atoms, and Q_2 and Q_7 may be each independently selected from the group consisting of a phenyl group, a naphthyl group, an anthryl group, a pyridinyl group, and a pyrazinyl group.

[0133] For example, L_1 , in Formula 2 and/or 3, may be selected from the group consisting of a phenylene group, a naphthylene group, an anthrylene group, a pyridinylene group, and a pyrazinylene group. In particular, L_1 may be a phenylene group or a pyridinylene group. For example, "a" may be 1, 2, or, 3.

[0134] The matrix compound for the ETL-layer may be further selected from Compound 5, 6, or 7 below:

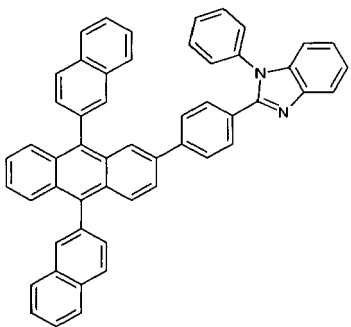
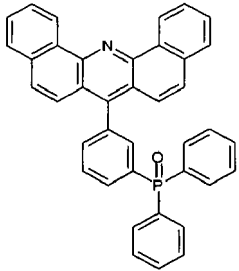
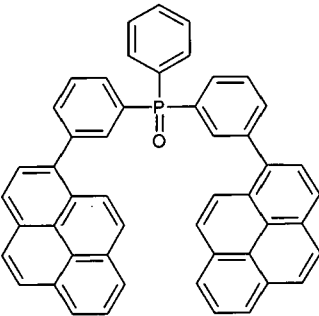
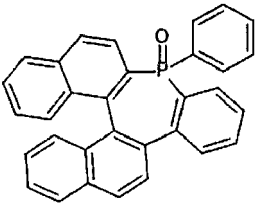


Compound 6

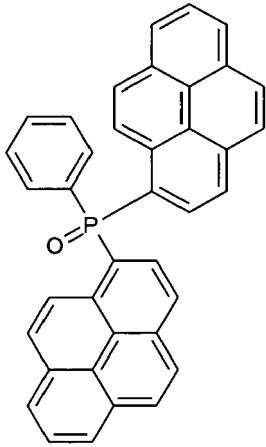
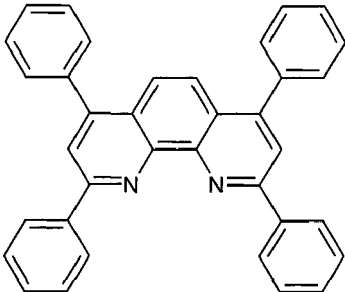
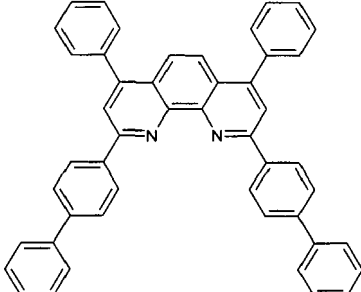
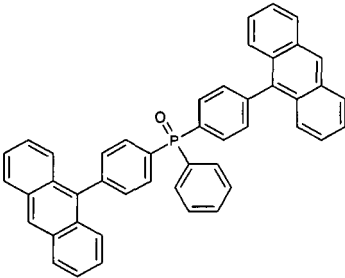


Compound 7.

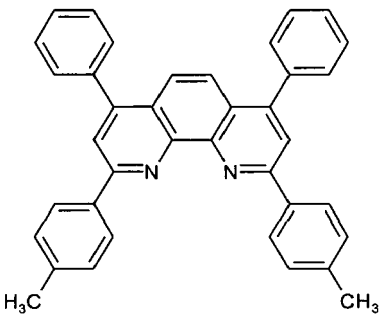
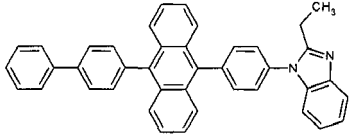
Table 2

Chemical structures of matrix materials that can be suitable used for ETL- and /or EIL-layer			
Compound	Name	Structure	Publication
MX 1	2-(4-(9,10-di(naphthalen-2-yl)anthracen-2-yl)phenyl)-1-phenyl-1H-benzo[d]imidazole		US 6878469 B2
MX 2	(3-(dibenzo[c,h]acridin-7-yl)phenyl)diphenylphosphine oxide		EP 2395571B1, WO2013079217A1
MX3	Phenylbis(3-(pyren-1-yl)phenyl)phosphine oxide		EP13187905.8
MX 4	3-Phenyl-3H-benzo[b]dinaphtho[2,1-d:1',2'-f]phosphine-3-oxide		EP13199361.0

(continued)

Chemical structures of matrix materials that can be suitable used for ETL- and /or EIL-layer			
Compound	Name	Structure	Publication
MX 5	Phenyldi(pyren-1-yl)phosphine oxide		JP4876333
MX 6	2,4,7,9-tetraphenyl-1,10-phenanthroline		EP1786050
MX 8	2,9-di(biphenyl-4-yl)-4,7-diphenyl-1,10-phenanthroline		EP1786050
MX 9	bis(4-(anthracen-9-yl)phenyl)(phenyl)phosphine oxide		EP13187905

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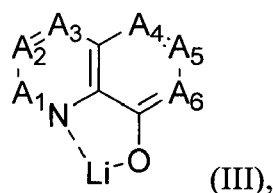
Chemical structures of matrix materials that can be suitable used for ETL- and /or EIL-layer			
Compound	Name	Structure	Publication
MX 10	4,7-diphenyl-2,9-di-p-tolyl-1,10-phenanthroline		EP1786050
MX 11	1-(4-(10-([1,1'-biphenyl]-4-yl)anthracen-9-yl)phenyl)-2-ethyl-1H-benzo[d]imidazole		WO2010134352

[0135] The electron transport layer may comprises a lithium halide or a lithium organic complex.

[0136] Suitable organic ligands to form a lithium organic complex that can be used for the electron transport layer are disclosed, for example, in US 2014/0048792 and Kathirgamanathan, Poopathy; Arkley, Vincent; Surendrakumar, Sivagnanasundram; Chan, Yun F.; Ravichandran, Seenivasagam; Ganeshamurugan, Subramaniam; Kumaraverl, Muttulingam; Antipan-Lara, Juan; Paramaswara, Gnanamolly; Reddy, Vanga R., Digest of Technical Papers - Society for Information Display International Symposium (2010), 41(Bk. 1), 465-468.

[0137] The organic ligand of the lithium organic complex of the electron transport layer may be selected from the group comprising a quinolate, a borate, a phenolate, a pyridinolate or a Schiff base ligand, or Table 1;

- preferably the lithium quinolate complex has the formula III:

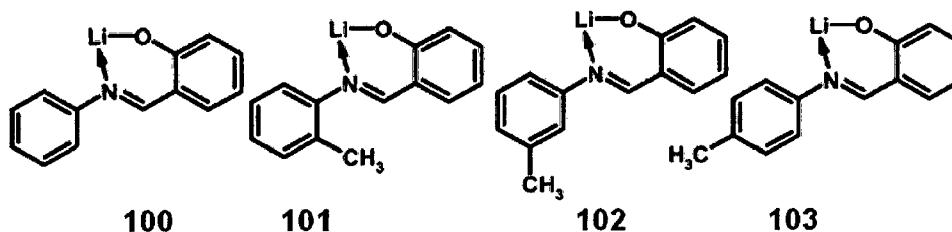


wherein

A₁ to A₆ are same or independently selected from CH, CR, N, O;

R is same or independently selected from hydrogen, halogen, alkyl or aryl or heteroaryl with 1 to 20 carbon atoms; and more preferred A₁ to A₆ are CH;

- preferably the borate based organic ligand is a tetra(1H-pyrazol-1-yl)borate;
- preferably the phenolate is a 2-(pyridin-2-yl)phenolate or a 2-(diphenylphosphoryl)phenolate;
- preferably the lithium Schiff base has the structure 100, 101, 102 or 103:



- more preferred the lithium organic complex is selected from a compound of Table 1.

The lithium halide of the electron transport layer may be selected from the group comprising a LiF, LiCl, LiBr or LiI, and preferably LiF.

[0138] The ETL may be formed on the EML by vacuum deposition, spin coating, slot-die coating, printing, casting, or the like. When the ETL is formed by vacuum deposition or spin coating, the deposition and coating conditions may be similar to those for formation of the HIL 130. However, the deposition and coating conditions may vary, according to a compound that is used to form the ETL.

Electron injection layer (EIL)

[0139] The optional EIL, which may facilitates injection of electrons from the cathode, may be formed on the ETL, preferably directly on the electron transport layer. Examples of materials for forming the EIL include LiQ, LiF, NaCl, CsF, Li₂O, BaO, Ca, Ba, Yb, Mg which are known in the art. Deposition and coating conditions for forming the EIL are similar to those for formation of the HIL, although the deposition and coating conditions may vary, according to a material that is used to form the EIL.

[0140] The thickness of the EIL may be in the range of about 0.1 nm to 10 nm, for example, in the range of 0.5 nm to 9 nm. When the thickness of the EIL is within this range, the EIL may have satisfactory electron-injecting properties, without a substantial increase in driving voltage.

Cathode electrode

[0141] The cathode electrode is formed on the EIL if present. The cathode electrode may be a cathode, which is an electron-injecting electrode. The cathode electrode may be formed of a metal, an alloy, an electrically conductive compound, or a mixture thereof. The cathode electrode may have a low work function. For example, the cathode electrode may be formed of lithium (Li), magnesium (Mg), aluminum (Al), aluminum (Al)-lithium (Li), calcium (Ca), barium (Ba), ytterbium (Yb), magnesium (Mg)-indium (In), magnesium (Mg)-silver (Ag), or the like. In addition, the cathode electrode may be formed of a transparent conductive material, such as ITO or IZO.

[0142] The thickness of the cathode electrode may be in the range of about 5 nm to 1000 nm, for example, in the range of 10 nm to 100 nm. When the cathode electrode is in the range of 5 nm to 50 nm, the electrode will transparent even if a metal or metal alloy is used.

[0143] The cathode electrode is not an electron injection layer or electron transport layer.

[0144] Since the layers of the ETL have similar or identical energy levels, the injection and transport of the electrons may be controlled, and the holes may be efficiently blocked. Thus, the OLED may have long lifetime.

Charge generation layer

[0145] The charge generation layer (CGL) 140 is composed of a double layer.

[0146] To be more specific, the charge generation layer can be a pn junction charge generation layer joining n-type charge generation layer 185 and p-type charge generation layer 135. The pn junction charge generation layer generates charges or separates them into holes and electrons; and injects the charges into the individual light emission layer. In other words, the n-type charge generation layer 185 provides electrons for the first light emission layer 150 near the anode while the p-type charge generation layer 135 provides holes to the second light emission layer 151 near the cathode 190, by which luminous efficiency of an organic light emitting device incorporating multiple light emission layers can be further improved and at the same time, driving voltage can be lowered.

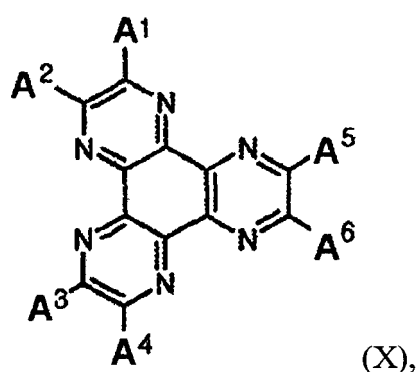
[0147] The p-type charge generation layer 135 can be composed of metal or organic material doped with p-type dopant. Here, the metal can be one or an alloy consisting of two or more selected from a group consisting of Al, Cu, Fe, Pb, Zn, Au, Pt, W, In, Mo, Ni, and Ti. Also, p-type dopant and host used for organic material doped with the p-type can

employ conventional materials. For example, the p-type dopant can be one selected from a group consisting of tetrafluore-7,7,8,8-tetracyanoquinodimethane (F4-TCNQ), derivative of tetracyanoquinodimethane, radialene derivative, iodine, FeCl₃, FeF₃, and SbCl₅. Also, the host can be one selected from a group consisting of N,N'-di(naphthalen-1-yl)-N,N'-diphenyl-benzidine (NPB), N,N'-diphenyl-N,N'-bis(3-methylphenyl)-1,1-biphenyl-4,4'-diamine (TPD) and N,N',N'-tetranaphthyl-benzidine (TNB).

[0148] The n-type charge generation layer 185 can be composed of metal or organic material doped with n-type. The metal can be one selected from a group consisting of Li, Na, K, Rb, Cs, Mg, Ca, Sr, Ba, La, Ce, Sm, Eu, Tb, Dy, and Yb. Also, n-type dopant and host used for organic material doped with the n-type can employ conventional materials. For example, the n-type dopant can be alkali metal, alkali metal compound, alkali earth metal, or alkali earth metal compound. More specifically, the n-type dopant can be one selected from a group consisting of Cs, K, Rb, Mg, Na, Ca, Sr, Eu and Yb. The host material can be one selected from a group consisting of tris(8-hydroxyquinoline)aluminum, triazine, hydroxyquinoline derivative, benzazole derivative, and silole derivative.

[0149] In a preferred embodiment, the host material is selected from compound of formula (1).

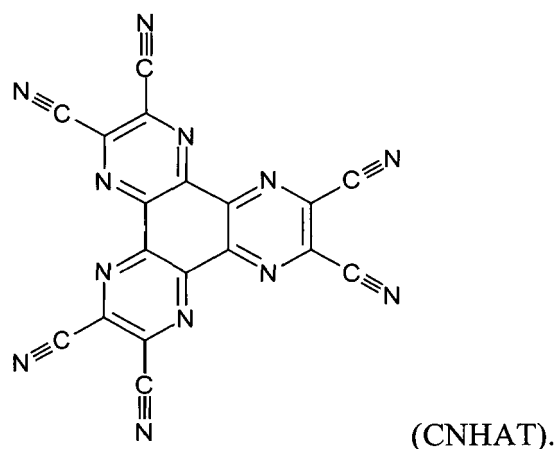
[0150] In another preferred embodiment, the electron transport layer comprised compound of formula (1) and an n-type charge generation layer (185), which is arranged adjacent to the electron transport layer. The n-type charge generation layer according to one example may include compounds of the following Chemical Formula X.



wherein

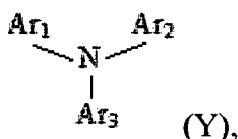
each of A¹ to A⁶ may be hydrogen, a halogen atom, nitrile (-CN), nitro (-NO₂), sulfonyl (-SO₂R), sulfoxide (-SOR), sulfonamide (-SO₂NR), sulfonate (-SO₃R), trifluoromethyl (-CF₃), ester (-COOR), amide (-CONHR or -CONRR'), substituted or unsubstituted straight-chain or branched-chain C₁-C₁₂ alkoxy, substituted or unsubstituted straight-chain or branched-chain C₁-C₁₂ alkyl, substituted or unsubstituted straight-chain or branched chain C₂-C₁₂ alkenyl, a substituted or unsubstituted aromatic or non-aromatic heteroring, substituted or unsubstituted aryl, substituted or unsubstituted mono- or di-arylamine, substituted or unsubstituted aralkylamine, or the like. Herein, each of the above R and R' may be substituted or unsubstituted C₁-C₆₀ alkyl, substituted or unsubstituted aryl, or a substituted or unsubstituted 5- to 7-membered heteroring, or the like.

[0151] Particularly preferred is an n-type charge generation layer comprising CNHAT



[0152] The p-type charge generation layer is arranged on top of the n-type charge generation layer. As the materials

for the p-type charge generation layer (135), aryl amine-based compounds may be used. One embodiment of the aryl amine-based compounds includes compounds of the following Chemical Formula Y:



wherein

Ar₁, Ar₂ and Ar₃ are each independently hydrogen or a hydrocarbon group.

[0153] Herein, at least one of Ar₁, Ar₂ and Ar₃ may include aromatic hydrocarbon substituents, and each substituent may be the same, or they may be composed of different substituents. When Ar₁, Ar₂ and Ar₃ are not aromatic hydrocarbons, they may be hydrogen; a straight-chain, branched-chain or cyclic aliphatic hydrocarbon; or a heterocyclic group including N, O, S or Se.

Organic light-emitting diode (OLED)

[0154] According to another aspect of the present invention, there is provided an organic light-emitting diode (OLED) comprising: a substrate; a anode electrode formed on the substrate; a hole injection layer, a hole transport layer, an emission layer, and a cathode electrode.

[0155] According to another aspect of the present invention, there is provided an organic light-emitting diode (OLED) comprising: a substrate; a anode electrode formed on the substrate; a hole injection layer, a hole transport layer, an electron blocking layer, an emission layer, hole blocking layer and a cathode electrode.

[0156] According to another aspect of the present invention, there is provided an organic light-emitting diode (OLED) comprising: a substrate; a anode electrode formed on the substrate; a hole injection layer, a hole transport layer, and electron blocking layer, an emission layer, hole blocking layer, electron transport layer, and a cathode electrode.

[0157] According to another aspect of the present invention, there is provided an organic light-emitting diode (OLED) comprising: a substrate; a anode electrode formed on the substrate; a hole injection layer, a hole transport layer, an electron blocking layer, an emission layer, hole blocking layer, electron transport layer, an electron injection layer, and a cathode electrode.

[0158] According to various embodiments of the present invention, there is provided an organic light-emitting diode (OLED) further comprising an electron injection layer formed between the electron transport layer and the cathode electrode.

[0159] According to various embodiments of the OLED of the present invention, the OLED may not comprises an electron injection layer.

[0160] According to various embodiments of the OLED of the present invention, the OLED may not comprises an electron transport layer.

[0161] According to various embodiments of the OLED of the present invention, the OLED may not comprises an electron transport layer and an electron injection layer.

[0162] According to one aspect an OLED can comprise a layer structure of a substrate that is adjacent arranged to an anode electrode, the anode electrode is adjacent arranged to a first hole injection layer, the first hole injection layer is adjacent arranged to a first hole transport layer, the first hole transport layer is adjacent arranged to a first electron blocking layer, the first electron blocking layer is adjacent arranged to a first emission layer, the first emission layer is adjacent arranged to a first electron transport layer, the first electron transport layer is adjacent arranged to an n-type charge generation layer, the n-type charge generation layer is adjacent arranged to a p-type charge generation layer, the p-type charge generation layer is adjacent arranged to a second hole injection layer, the second hole injection layer is adjacent arranged to a second hole transport layer, the second hole transport layer is adjacent arranged to a second electron blocking layer, the second electron blocking layer is adjacent arranged to a second emission layer, between the second emission layer and the cathode electrode an optional electron transport layer and/or an optional injection layer are arranged.

[0163] According to another aspect of the present invention, there is provided a method of manufacturing an organic light-emitting diode (OLED), the method using:

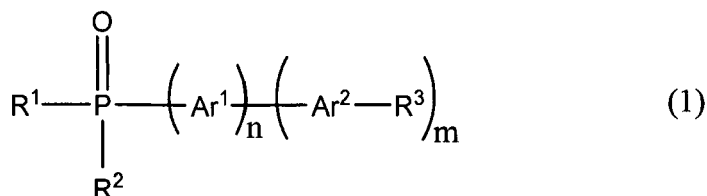
- at least one deposition source, preferably two deposition sources and more preferred at least three deposition sources; and/or
- deposition via vacuum thermal evaporation; and/or
- deposition via solution processing, preferably the processing is selected from spin-coating, printing, casting and/or

slot-die coating.

[0164] According to another aspect, there is provided a method comprising the steps, wherein

- on a substrate (110) an anode (120) is formed,
- on the anode (120) an emission layer (150) is formed,
- on the emission layer (150) an electron transport layer (160) is formed,
- on the electron transport layer (160) a cathode electrode (190) is formed,
- optional a hole injection layer (130), a hole transport layer (140), an electron blocking layer (145), an emission layer (150), and a hole blocking layer, are formed in that order between the at least anode (120) and the electron transport layer (160),
- optional an electron injection layer (180) is arranged between the electron transport layer (160) and the cathode (190).

[0165] Finally, the object is achieved by a compound of formula (1)



wherein R¹ and R² are each independently selected from C₁ to C₁₆ alkyl;

Ar¹ is selected from C₆ to C₁₄ arylene or C₃ to C₁₂ heteroarylene;

Ar² is independently selected from C₁₄ to C₄₀ arylene comprising a conjugated system of at least 14 delocalized electrons or C₈ to C₄₀ heteroarylene comprising a conjugated system of at least 14 delocalized electrons;

R³ is independently selected from H, C₁ to C₁₂ alkyl or C₁₀ to C₂₀ aryl;

Ar¹, Ar² and R³ may each independently be unsubstituted or substituted with at least one C₁ to C₁₂ alkyl group;

n is 0 or 1;

m is 1 in case of n = 0; and m is 1 or 2 in case of n = 1; and

wherein compounds with R¹ and R² being iso-propyl, n being 0 and Ar² being anthracenylene or phenanthrylene and R³ being H are excluded.

[0166] Definitions and explanations provided with respect to the compounds of formula (1) in the organic semiconductive layer are also true with respect to the inventive compound and throughout the whole application text.

[0167] To simplify the synthesis of the inventive compounds, it may be preferred that R¹ and R² are selected the same. That is, it is preferred that R¹ and R² are the same C₁ to C₁₆ alkyl group.

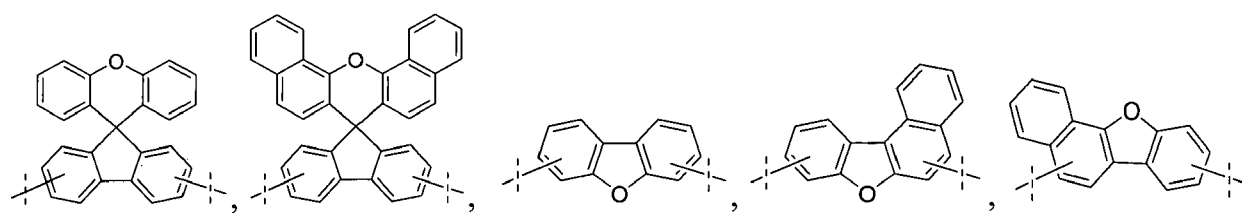
[0168] To adjust the chemical and physical properties, such as solubility, of the inventive compound, it may be preferred that R¹ and R² are each independently selected from C₁ to C₁₀ alkyl, preferably C₁ to C₈ alkyl, more preferably C₁ to C₆ alkyl, further preferred C₁ to C₄ alkyl.

[0169] It is further preferred that Ar¹ is selected from a group consisting of phenylene, biphenylene, naphthylene, fluorenylene, pyridylene, quinolinylen and pyrimidinylene.

[0170] It is further preferred that Ar¹ is selected from C₆ to C₁₄ arylene.

[0171] It is likewise preferred that n is 1.

[0172] Furthermore, it is preferred that Ar² is selected from a group consisting of pyrenylene, carbazoylene, benzo[c]acridinylene, dibenzo[c,h]acridinylene, dibenzo[a,j]acridinylene or from a group of the following formulas (IVa) to (IVm),



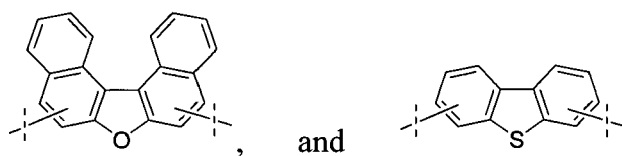
(IVa)

(IVb)

(IVc)

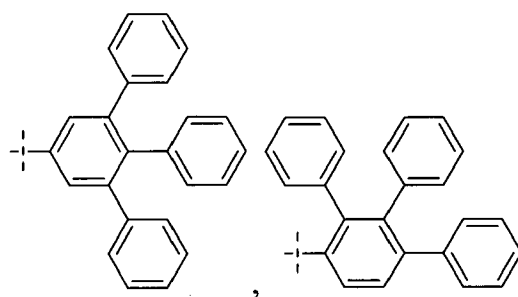
(IVd)

(IVe)



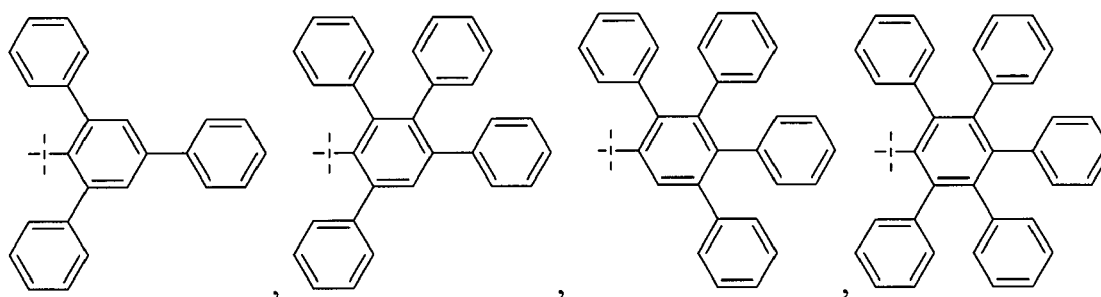
(IVf)

(IVg)



(IVh)

(IVi)



(IVj)

(IVk)

(IVl)

(IVm).

[0173] Furthermore preferred, Ar² is selected from a group consisting of pyrenylene, benzo[c]acridinylene, dibenzo[c,h]acridinylene and dibenzo[a,j]acridinylene.

[0174] More preferred, Ar² is selected from C₁₄ to C₄₀ arylene, preferably, C₁₄ to C₂₂ arylene.

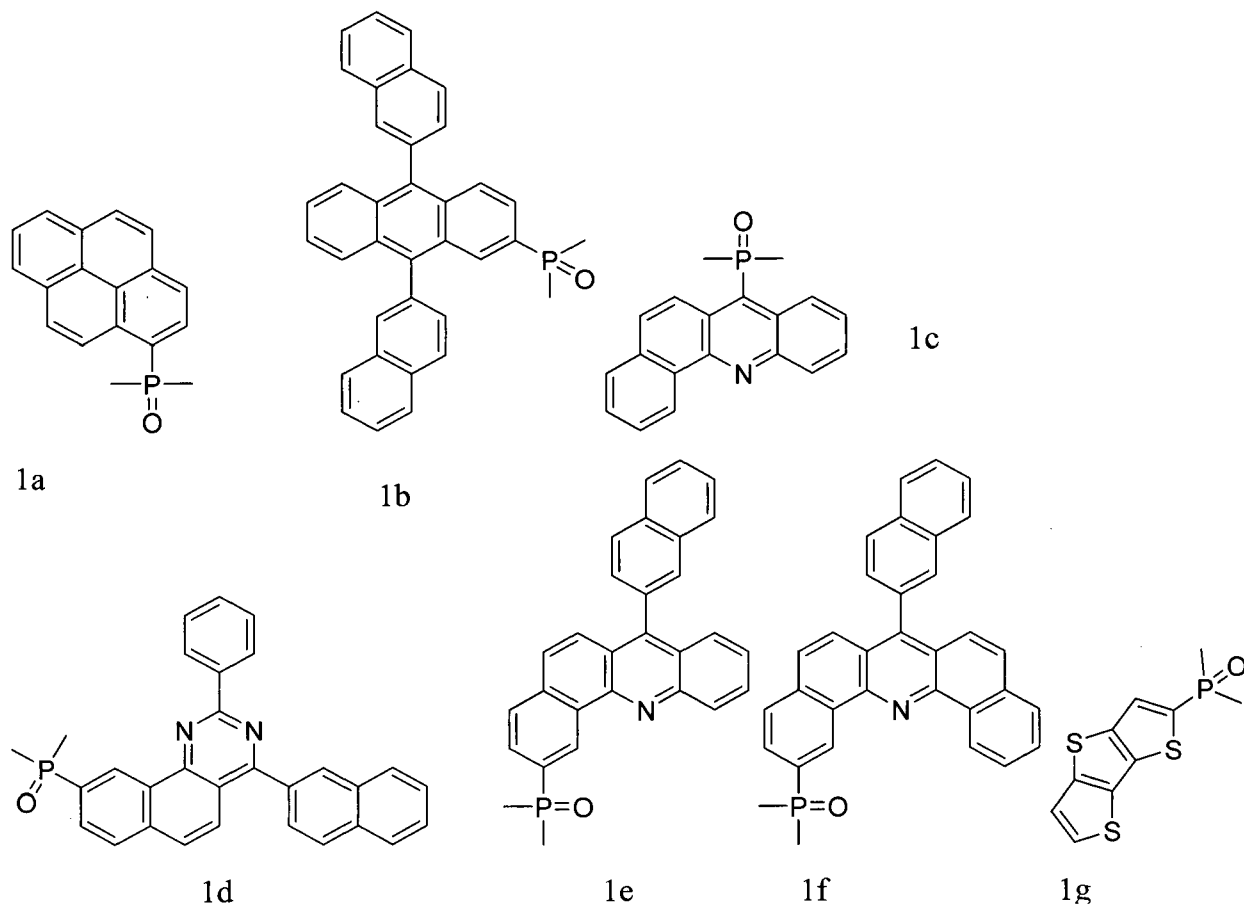
[0175] In a preferred embodiment, R^3 is selected from H, phenyl, biphenyl, terphenyl, fluorenyl, naphthyl, phenanthryl, pyrenyl, carbazoyl, dibenzofuranyl or dinaphthofuranyl, preferably from H, phenyl, biphenyl or naphthyl.

[0176] In the preferred embodiment where R^3 is selected from the above-mentioned preferred embodiments, the physical properties are particularly suited to industrial applications.

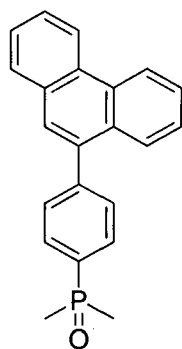
[0177] Likewise, it is preferred that Ar^1 , Ar^2 and R^3 are each independently unsubstituted or substituted with at least one C_1 to C_6 alkyl group, preferably C_1 to C_4 alkyl group.

[0178] Most preferred, Ar^1 , Ar^2 and R^3 are unsubstituted.

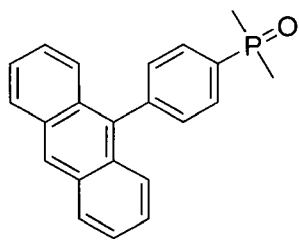
[0179] In an embodiment, n is 0 and m is 1. Preferred compound of formula (1) according to the invention is selected from one of the following compounds 1a to 1g.



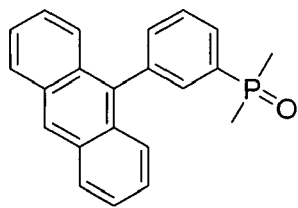
[0180] In a further embodiment, n is 1 and m is 1 and R^3 is H. Preferred compound of formula (1) according to the invention is selected from one of the following compounds 2a to 2v.



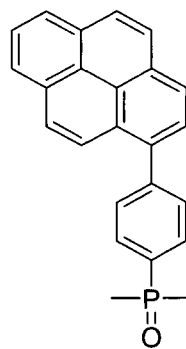
2a



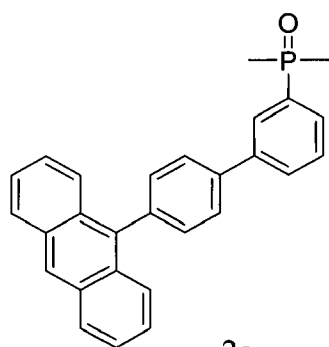
2b



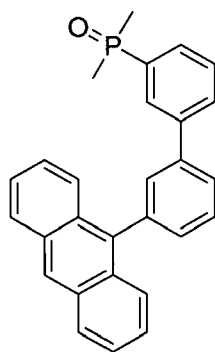
2c



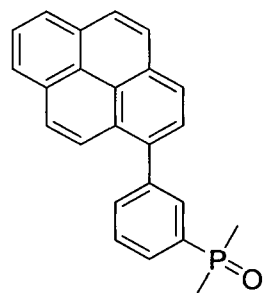
2d



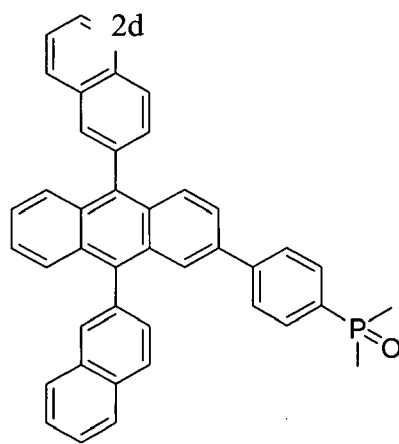
2e



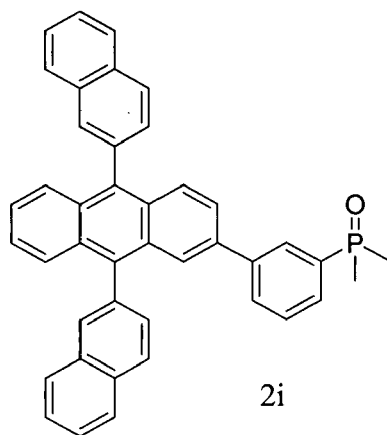
2f



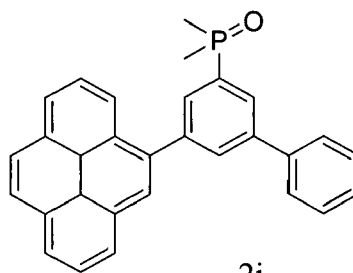
2g



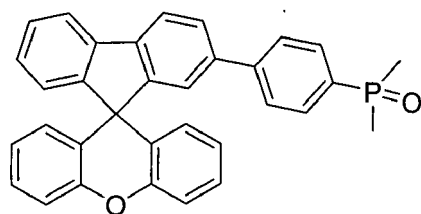
2h



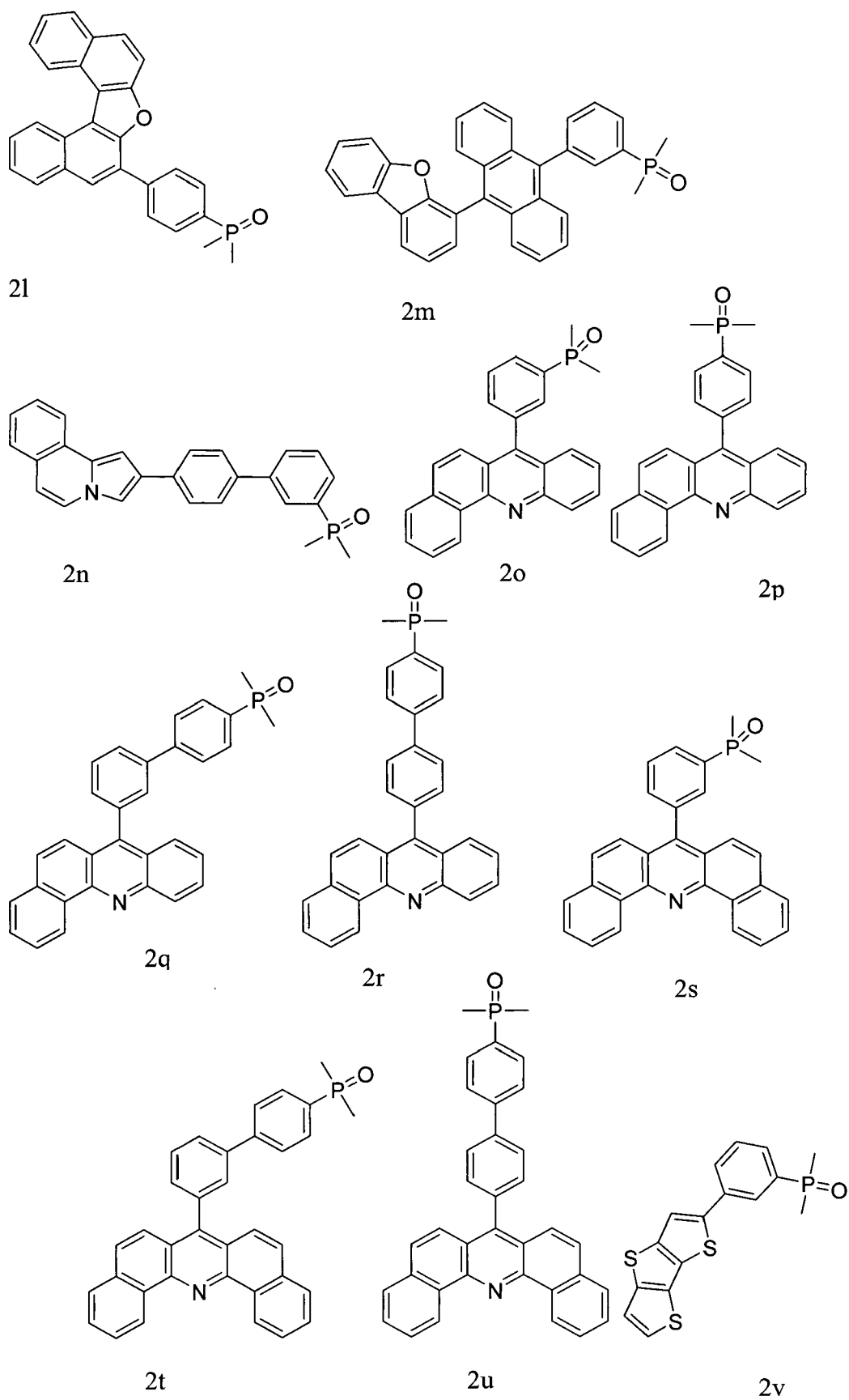
2i



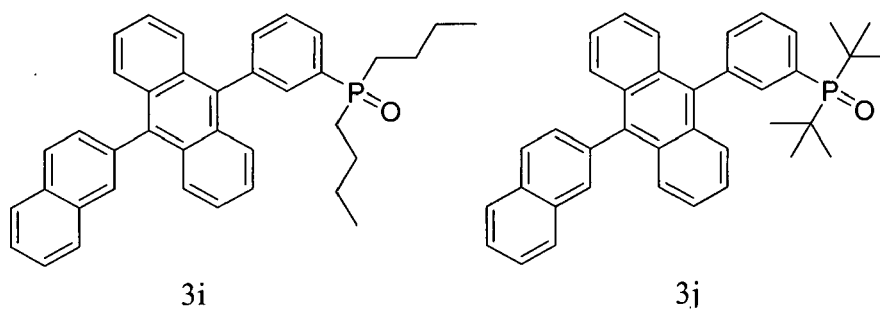
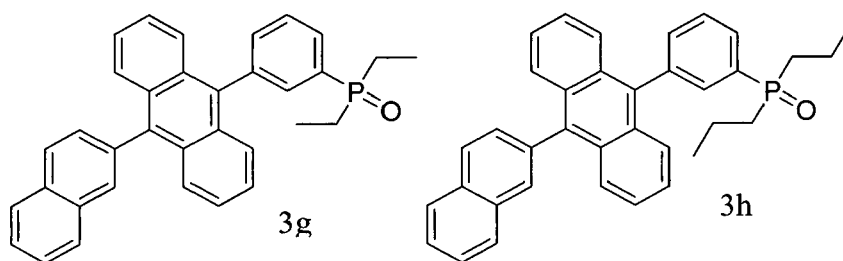
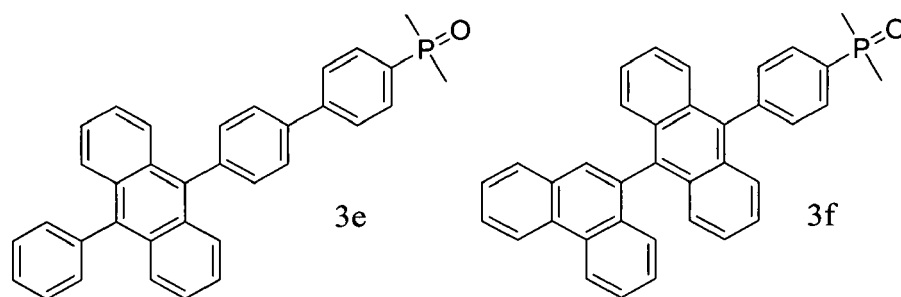
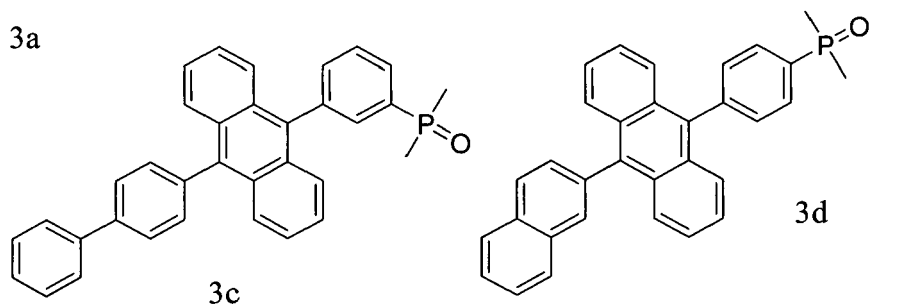
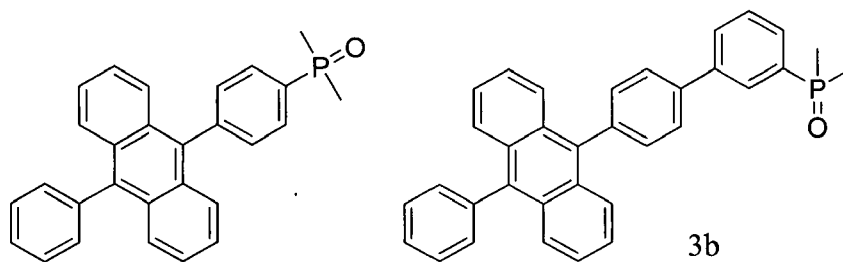
2j

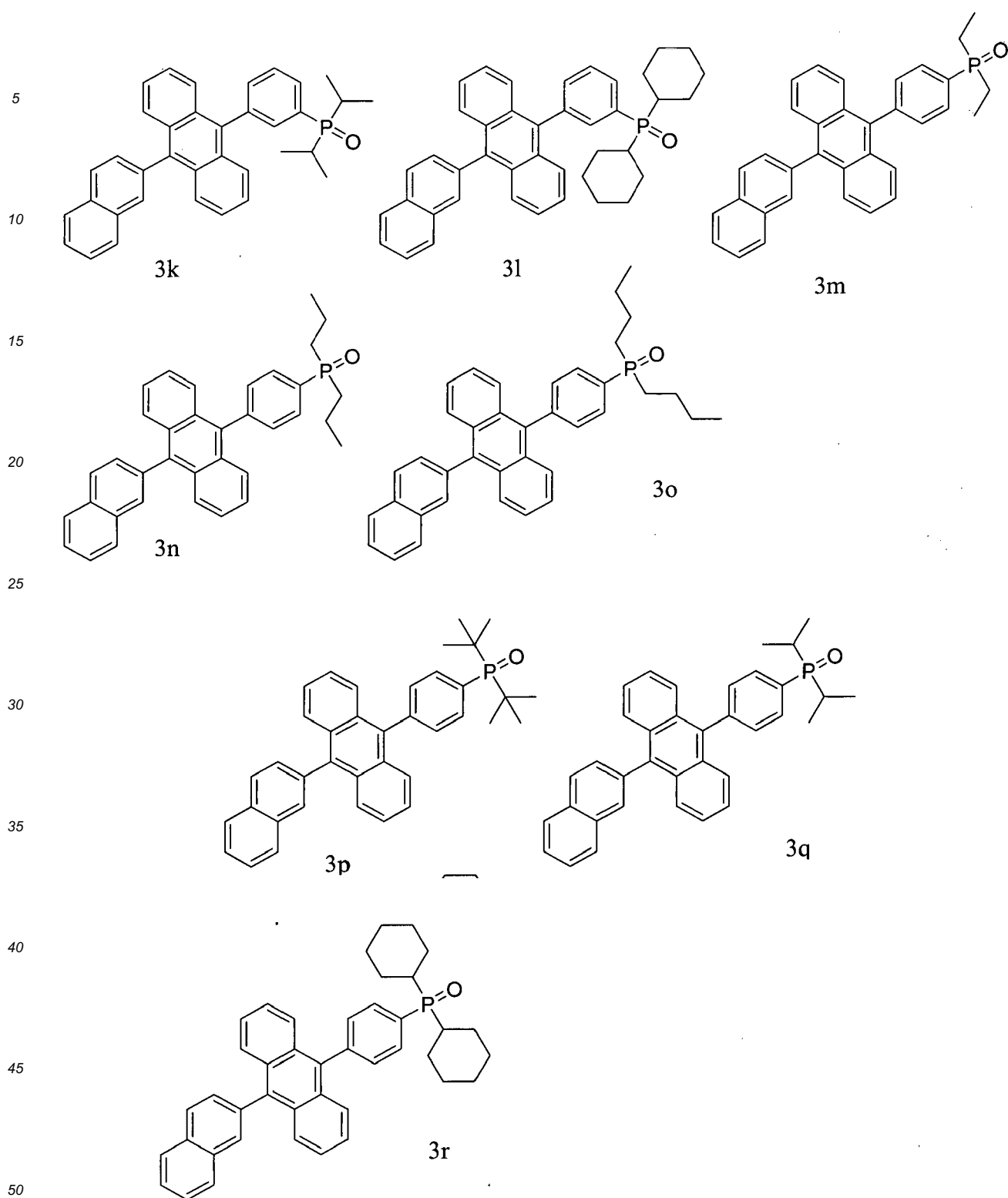


2k



[0181] In a further embodiment, n is 1 and m is 1 and R^3 is C_1 to C_{12} alkyl or C_{10} to C_{20} aryl. Preferred compound of formula (1) according to the invention is selected from one of the following compounds 3a to 3r.



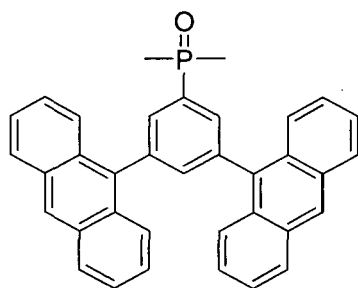


[0182] In a further embodiment, n is 1 and m is 2. Preferred compound of formula (1) according to the invention is selected from one of the following compounds 4a to 4f.

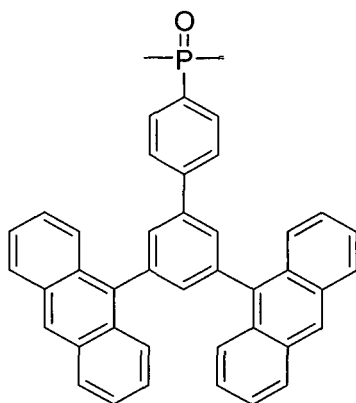
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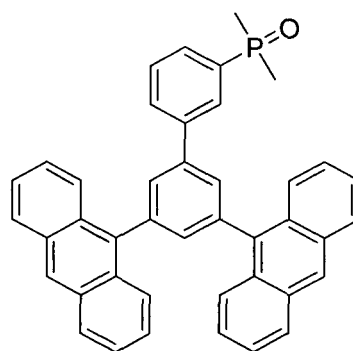
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4a



4b

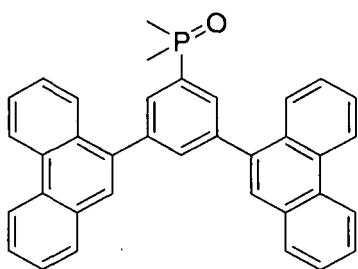


4c

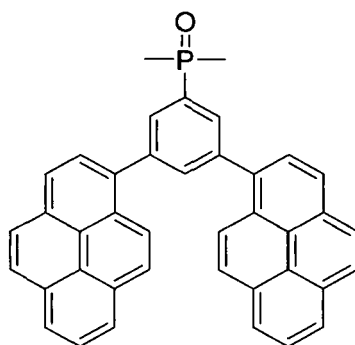
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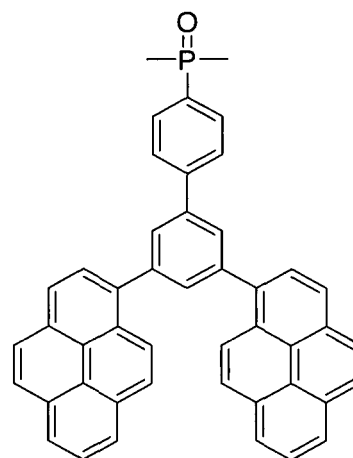
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4d



4e



4f

35

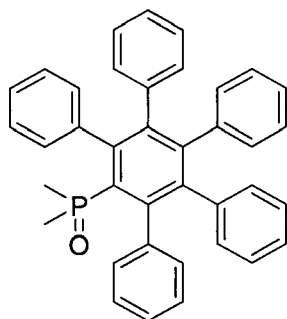
[0183] In a further embodiment, Ar² is selected from particularly bulky substituents. Bulky substituents of the type shown below have a rigid 3D structure which has been found to be particularly preferable. Preferred compound of formula (1) according to the invention is selected from one of the following compounds 5a to 5c.

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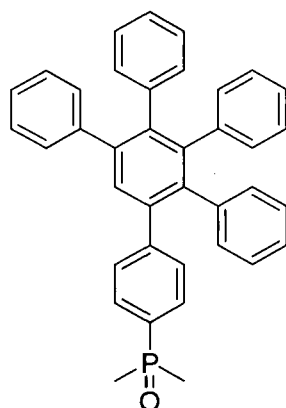
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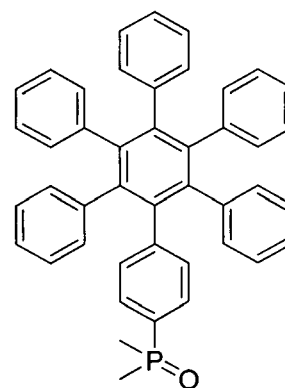
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5a



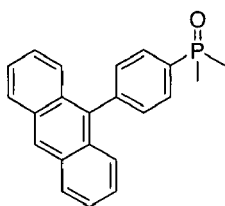
5b



5c

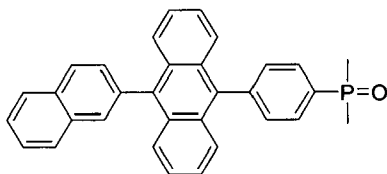
[0184] Finally, it is preferred that the compound is selected from one of the following compounds a to g

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(a)

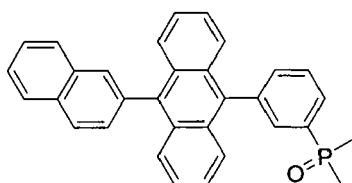
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(b)

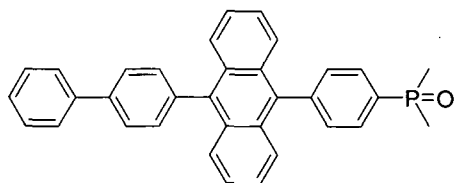
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(c)

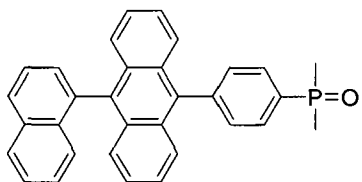
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(d)

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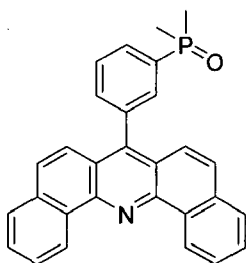
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(e)

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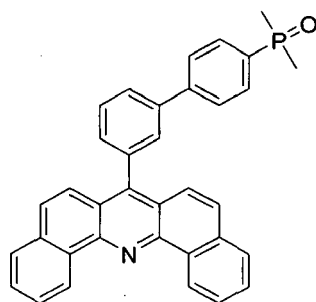
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(f)

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(g).

[0185] It was surprisingly found by the inventors that improved performance of OLEDs known in the art can be achieved by replacing diaryl phosphine oxide compounds (known in the art) by dialkyl phosphine oxide compounds (in accordance with the invention) in the electron transport/injection layer.

[0186] A beneficial effect is noticeable in a layer which is free of dopant, as well as in a doped layer, particularly when doped with lithium organic complex or zero-valent metal.

[0187] A variety of dialkyl phosphine oxide compounds has been investigated and observed to show a particular beneficial effect. In detail, the organic semiconductive layer, the device and the compounds disclosed above were suitable to solve the problem underlying the present invention by featuring reduced drive voltage and/or improved external quantum efficiency and/or improved lifetime of OLEDs.

[0188] Further particular preferred embodiments of the present invention are related to organic light-emitting diodes (OLED). Preferred embodiments in this regard are as follows.

BRIEF DESCRIPTION OF THE DRAWINGS

[0189] These and/or other aspects and advantages of the present invention will become apparent and more readily appreciated from the following description of the exemplary embodiments, taken in conjunction with the accompanying drawings, of which:

FIG. 1 is a schematic sectional view of an organic light-emitting diode (OLED), according to an exemplary embodiment of the present invention;

FIG. 2 is a schematic sectional view of an OLED, according to an exemplary embodiment of the present invention.

FIG. 3 is a schematic sectional view of a tandem OLED comprising a charge generation layer, according to an exemplary embodiment of the present invention.

DETAILED DESCRIPTION

[0190] Reference will now be made in detail to the exemplary embodiments of the present invention, examples of which are illustrated in the accompanying drawings, wherein like reference numerals refer to the like elements throughout. The exemplary embodiments are described below, in order to explain the aspects of the present invention, by referring to the figures.

[0191] Herein, when a first element is referred to as being formed or disposed "on" a second element, the first element can be disposed directly on the second element, or one or more other elements may be disposed there between. When a first element is referred to as being formed or disposed "directly on" a second element, no other elements are disposed there between.

[0192] FIG. 1 is a schematic sectional view of an organic light-emitting diode (OLED) 100, according to an exemplary embodiment of the present invention. The OLED 100 includes a substrate 110, an anode 120, a hole injection layer (HIL) 130, a hole transport layer (HTL) 140, an emission layer (EML) 150, an electron transport layer (ETL) 160. The electron transport layer (ETL) 160 comprising or consisting of the compound of formula (1) is formed directly on the EML 150. Onto the electron transport layer (ETL) 160 an electron injection layer (EIL) 180 is disposed. The cathode 190 is disposed directly onto the electron injection layer (EIL) 180.

[0193] Instead of a single electron transport layer 160, optional an electron transport layer stack (ETL) can be used.

[0194] Fig. 2 is a schematic sectional view of an OLED 100, according to another exemplary embodiment of the present invention. Fig. 2 differs from Fig. 1 in that the OLED 100 of Fig. 2 comprises an electron blocking layer (EBL) 145 and a hole blocking layer (HBL) 155.

[0195] Referring to Fig. 2 the OLED 100 includes a substrate 110, an anode 120, a hole injection layer (HIL) 130, a hole transport layer (HTL) 140, an electron blocking layer (EBL) 145, an emission layer (EML) 150, a hole blocking layer

(HBL) 155, an electron transport layer (ETL) 160, an electron injection layer (EIL) 180 and a cathode electrode 190. The electron transport layer (ETL) 160 and/or the electron injection layer (EIL) 180 comprise or consist of the compound of formula (1).

[0196] In the description above the method of manufacture an OLED 100 of the present invention is started with a substrate 110 onto which an anode 120 is formed, on the anode electrode 120, an hole injection layer 130, hole transport layer 140, optional an electron blocking layer 145, an emission layer 150, optional a hole blocking layer 155, optional at least one electron transport layer 160, optional at least one electron injection layer 180, and a cathode 190 are formed, in that order or the other way around.

[0197] Fig. 3 is a schematic sectional view of a tandem OLED 200, according to another exemplary embodiment of the present invention. Fig. 3 differs from Fig. 2 in that the OLED 100 of Fig. 3 further comprises a charge generation layer and a second emission layer.

[0198] Referring to Fig. 3 the OLED 200 includes a substrate 110, an anode 120, a first hole injection layer (HIL) 130, a first hole transport layer (HTL) 140, a first electron blocking layer (EBL) 145, a first emission layer (EML) 150, a first hole blocking layer (HBL) 155, a first electron transport layer (ETL) 160, an n-type charge generation layer (n-type CGL) 185 which may comprise compound of formula (1), a p-type charge generation layer (p-type GCL) 135, a second hole transport layer (HTL) 141, a second electron blocking layer (EBL) 146, a second emission layer (EML) 151, a second hole blocking layer (EBL) 156, a second electron transport layer (ETL) 161, a second electron injection layer (EIL) 181 and a cathode 190. The electron transport layers (ETL) 160 and 161 and/or the electron injection layer (EIL) 180 and/or the n-type charge generation layer (n-type CGL) 185 comprise or consist of the compound of formula (1).

[0199] In the description above the method of manufacture an OLED 200 of the present invention is started with a substrate 110 onto which an anode 120 is formed, on the anode electrode 120, a first hole injection layer 130, first hole transport layer 140, optional a first electron blocking layer 145, a first emission layer 150, optional a first hole blocking layer 155, optional at least one first electron transport layer 160, an n-type CGL 185, a p-type CGL 135, a second hole transport layer 141, optional a second electron blocking layer 146, a second emission layer 151, an optional second hole blocking layer 156, an optional at least one second electron transport layer 161, an optional electron injection layer 181, and a cathode 190 are formed, in that order or the other way around.

[0200] While not shown in Fig. 1, Fig. 2 and Fig. 3, a sealing layer may further be formed on the cathode electrodes 190, in order to seal the OLEDs 100 and 200. In addition, various other modifications may be applied thereto.

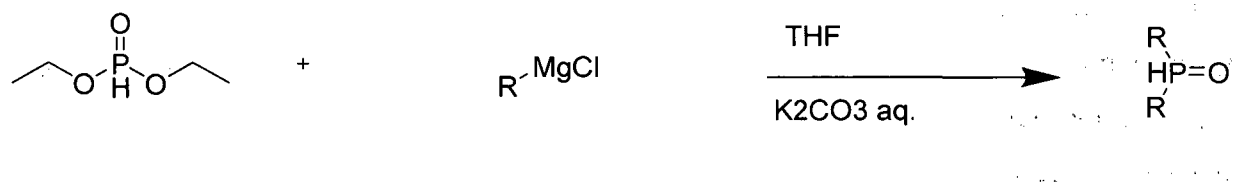
[0201] Hereinafter, one or more exemplary embodiments of the present invention will be described in detail with, reference to the following examples. However, these examples are not intended to limit the purpose and scope of the one or more exemplary embodiments of the present invention.

Examples

Preparation of compounds of formula (1)

Synthesis of dialkylphosphine oxide with $R^1 = R^2$

[0202]



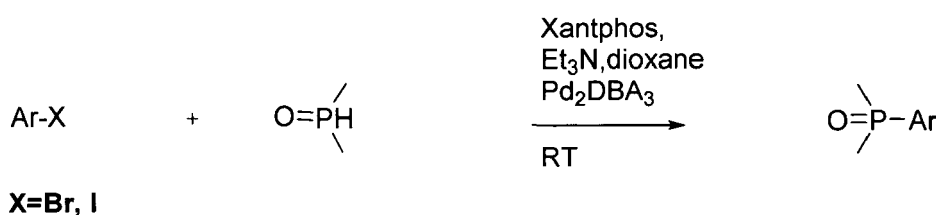
[0203] Dialkylphosphine oxides were prepared using a known procedure (Hays, R.H., The Journal of Organic Chemistry 1968 33 (10), 3690-3694)

Diethyl phosphonate (0.95 eq) is added to an ice cooled Grignard solution in THF (3 eq) at such a rate that a temperature of the reaction mixture is maintained at 20-30°C After stirring at room temperature for 1 h the mixture is hydrolyzed by mixing it with an ice-cold saturated aqueous solution of potassium carbonate (3 eq). Precipitated magnesium carbonate is removed by filtration and washed several time with ethanol. Combined filtrates are concentrated in vacuum to give a crude material, which could be further purified by distillation or re-crystallization from an appropriate solvent.

Starting materials and products		
Starting compound	Product	Yield / MS data
Methylmagnesium chloride	Dimethylphosphine oxide	70.8 % / 78[M] ⁺
Ethylmagnesium bromide	Diethylphosphine oxide	
Isopropylmagnesium bromide	Diisopropylphosphine oxide	
Tert-butylmagnesium bromide	Di-tert-butylphosphine oxide	
Butylmagnesium bromide	Dibutylphosphine oxide	
Cyclohexylmagnesium bromide	Dicyclohexylphosphine oxide	

Typical procedure for coupling of dialkylphosphine oxide with arylhalides

[0204]



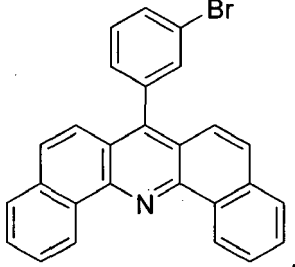
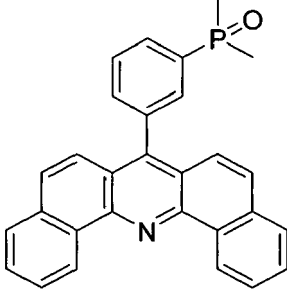
[0205] Schlenk flask is charged with arylhalide (1 eq), dialkylphosphine oxide (1 eq.) and sealed with a rubber septum. Atmosphere is replaced by Argon and the starting compounds are dissolved in anhydrous dioxane or suspended in dioxane-THF mixture (1:1 vol.) In a separate vial, a mixture of tris(dibenzylideneacetone)dipalladium (0.005eq), Xantphos (0.01eq) and triethylamine (1.17eq.) is dissolved in anhydrous dioxane (75ml/mmol) at 24 °C for 10 min. This catalyst solution is added to the mixture of phosphine oxide and aryl halide and the reaction mixture was stirred for 12-24h at 24°C.

[0206] *Work up procedure 1:* A precipitated solid (trimethylamine salt) is separated by filtration through sintered glass filter (Pore size 4), washed two times with dioxane, combined filtrates are evaporated to a dryness under reduced pressure using a rotary evaporator. The residue is dissolved in water, pH is set to alkaline (~14) using aqueous potassium hydroxide solution. Resulting yellow turbid aqueous layer is sequentially extracted with hexane and diethyl ether. Combined organic layers are extracted with ~0.5M aqueous KOH solution, aqueous phases are combined, acidified by hydrochloric acid and extracted with dichloromethane. Combined extracts are washed with saturated sodium hydrocarbonate solution, brine and dried over magnesium sulfate. Solvent is removed under reduced pressure, residue is triturated with hexane, white crystalline precipitate is collected by vacuum filtration, washed with hexane and dried.

[0207] *Work up procedure 2:* Reaction mixture is diluted with water, precipitated material is collected by suction using a sintered glass filter (pore 4), washed with water, methanol and dried. Crude product could be further purified by recrystallization from appropriate solvent. Final purification is achieved by sublimation in a high vacuum.

Starting materials and products		
Starting compound(s)	Product/ (work-up procedure)	Yield / MS data
1-bromo-4-iodobenzene, dimethylphosphine oxide	(4-bromophenyl)dimethylphosphine oxide / (1)	75% / 232 [M] ⁺
1-bromo-3-iodobenzene, dimethylphosphine oxide	(3-bromophenyl)dimethylphosphine oxide /(1)	70.8 % / 232 [M] ⁺
Diisopropylphosphine oxide, 1-bromo-4-iodobenzene	(4-bromophenyl)diisopropylphosphine oxide /(1)	
Diisopropylphosphine oxide, 1-bromo-3-iodobenzene	(3-bromophenyl)diisopropylphosphine oxide	

(continued)

Starting materials and products		
Starting compound(s)	Product/ (work-up procedure)	Yield / MS data
	/ (1)	
Di-tert-butylphosphine oxide, 1-bromo-4-iodobenzene,	(4-bromophenyl)di-tert-butylphosphine oxide /(1)	
Di-tert-butylphosphine oxide, 1-bromo-3-iodobenzene	(3-bromophenyl)di-tert-butylphosphine oxide /(1)	
Dibutylphosphine oxide, 1-bromo-4-iodobenzene	(4-bromophenyl)dibutylphosphine oxide /(1)	
Dibutylphosphine oxide, 1-bromo-3-iodobenzene	(3-bromophenyl)Dibutylphosphine oxide /(1)	
Dicyclohexylphosphine oxide, 1-bromo-4-iodobenzene,	(4-bromophenyl)dicyclohexylphosphine oxide/ (1)	
Dicyclohexylphosphine oxide, 1-bromo-3-iodobenzene	(3-bromophenyl)Dicyclohexylphosphine oxide /(1)	
 dimethylphosphine oxide	 /2	76.5% / 432[M+H] ⁺ , 885 [2M+Na] ⁺

Procedures for Suzuki-Miyaura coupling

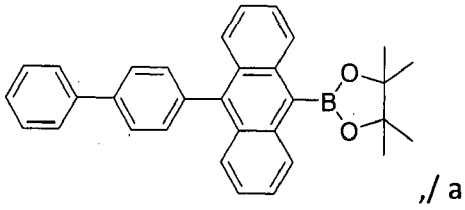
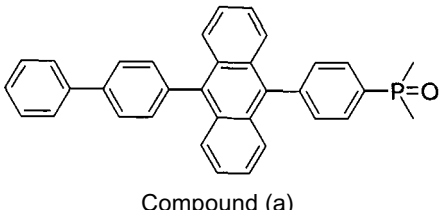
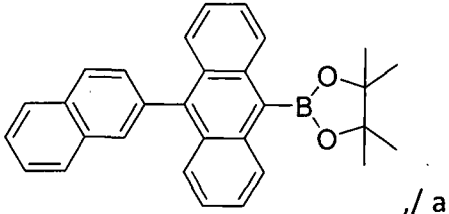
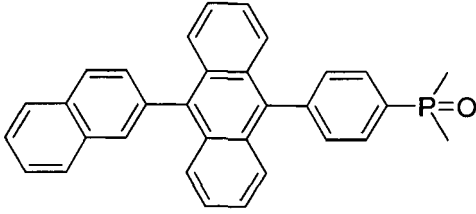
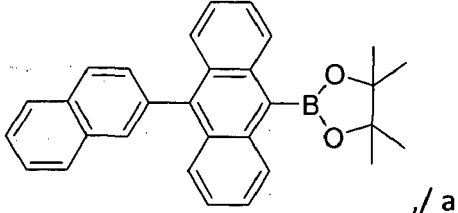
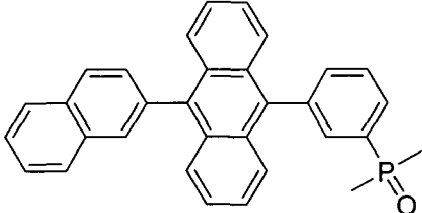
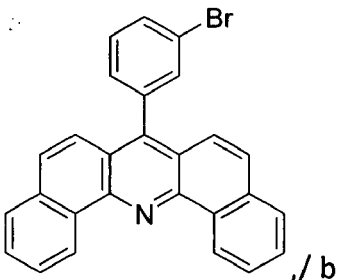
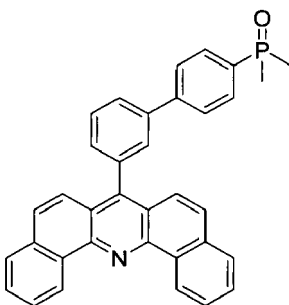
Method a.

[0208] A three neck round bottom flask, equipped with dropping funnel, reflux condenser and magnetic stir bar is charged with boronic ester (1 eq) and bromophenyldialkylphosphine oxide (1.5 eq), the flask is sealed with a rubber septum, evacuated and back-filled with argon (2 times). Anhydrous THF (10ml/mmol of boronic ester) is added through the septum using a double-tipped needle. Separately, a catalyst is prepared by suspending of bis(dibenzylidenacetone)palladium (0.02 eq) and tri-tert-butylphosphane (0.04 eq) in a small amount of anhydrous THF under Argon. The catalyst suspension is added to the reaction mixture through the septum with a syringe. Deoxygenated aqueous solution of tetrabutylammonium hydroxide (~20% wt., 2 eq) is added dropwise to the reaction mixture at room temperature (addition time ~30 min). Reaction mixture is stirred at room temperature for 2 h, precipitated product is separated by filtration, washed with water, methanol, and hexane, dried in vacuum at 40°C for 48h. Crude product is then triturated with hot dichloromethane/hexane mixture (1:1 vol, ~300ml), hot filtered and dried in vacuum at 50°C for 1 h and at 120° for 1 h. Final purification is achieved by sublimation in a high vacuum.

Method b.

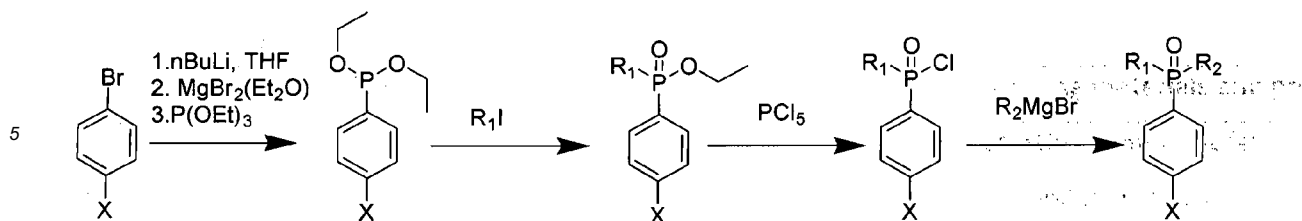
[0209] Potassium carbonate (51.4mmol, 3 eq.) is dissolved in ~25ml of deionized water, the solution is degassed with

N₂ for 30 min. Glyme (175ml) is degassed in a 500mL 3-necked round bottom flask with N₂ for 30 min. The flask is then charged with boronic ester (17.14mmol, 1 eq.), bromophenyldialkylphosphine oxide (17.99mmol, 1.05eq.) and tetrakis(triphenylphosphin)palladium(0) (0.51 mmol, 0.03 eq.) under a positive nitrogen pressure. The degassed potassium carbonate solution is added using a syringe, nitrogen purged reflux condenser is attached to the flask and a reaction mixture heated to 90°C with stirring for 12 h. The mixture is allowed to cool down to the room temperature, a precipitate is collected by filtration, washed with water, methanol, dried in vacuum at 40°C to give a crude product, which could be further purified by re-crystallization or trituration with appropriate solvents. Final purification is achieved by sublimation in a high vacuum.

Starting materials and products		
Starting compound(s), /coupling method	Product	Yield / MS data
 ./ a	 Compound (a)	89.6% / 483[M+H] ⁺
 ./ a	 Compound (b)	20.7% / 457[M] ⁺
 ./ a	 Compound (c)	71.3% / 457[M] ⁺
 ./ b	 Compound (f)	508[M] ⁺

Synthesis of asymmetrical dialkylphosphine oxides

[0210]



General Procedure for Diethyl Phosphonites

[0211] Aryl bromide (0.15 mol) is dissolved in dry tetrahydrofuran (150 mL) under N₂, the solution is cooled down to -78°C. nBuLi (0.158 mol, 1.05 eq) is added dropwise to the reaction mixture at this temperature, the mixture is stirred for 1 h at -78°C for additional 1 hour. Magnesium bromide ethyl etherate (0.165 mol, 1.1 eq) is added at this temperature, and the mixture is allowed to reach a room temperature during 1 h. Triethylphosphite (0.1 mol, 0.66 eq) is added in one portion at room temperature, the mixture is then stirred at 50° for additional 1-3 h to complete the reaction. After removal of the solvent under reduced pressure the crude materials is obtained. Further purification could be achieved by vacuum distillation.

Starting materials and products	
Starting compound(s)	Product
1,4-dibromobenzene	diethyl (4-bromophenyl)phosphonite
1,3-dibromobenzene	diethyl (3-bromophenyl)phosphonite

General Procedure for Phosphinate

[0212] The phosphonite (55.0 mmol) is added drop-wise to a two neck round bottom flask containing alkyl iodide (1.6 mmol, neat or a solution in THF) at a rate to maintain a steady reflux. The reaction was stirred for a further 18 h, and then purified via vacuum distillation.

Starting materials and products	
Starting compound(s)	Product
diethyl (4-bromophenyl)phosphonite	ethyl (4-bromophenyl)(methyl)phosphinate
diethyl (3-bromophenyl)phosphonite	ethyl (3-bromophenyl)(methyl)phosphinate
diethyl (4-bromophenyl)phosphonite	ethyl (4-bromophenyl)(ethyl)phosphinate
diethyl (3-bromophenyl)phosphonite	ethyl (3-bromophenyl)(ethyl)phosphinate

General Procedure for Phosphinic Chloride

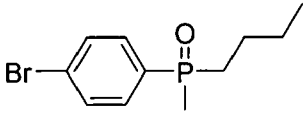
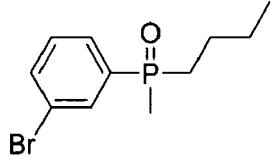
[0213] Phosphinate (35.0 mmol) is dissolved in 1,2-dichloroethane (30 ml) and phosphorus pentachloride (35.1 mmol) is added at a rate to maintain the temperature at 40°C. Following complete addition, the reaction is stirred overnight. The volatiles are removed under reduced pressure to afford a crude material, which could be further purified by vacuum distillation or re-crystallization from an appropriate solvent.

Starting materials and products	
Starting compound(s)	Product
ethyl (4-bromophenyl)(methyl)phosphinate	(4-bromophenyl)(methyl)phosphinic chloride
ethyl (3-bromophenyl)(methyl)phosphinate	(3-bromophenyl)(methyl)phosphinic chloride
ethyl (4-bromophenyl)(ethyl)phosphinate	(4-bromophenyl)(ethyl)phosphinic chloride
ethyl (3-bromophenyl)(ethyl)phosphinate	(3-bromophenyl)(ethyl)phosphinic chloride

General Procedure for Alkyl (alkyl) phosphine oxides

[0214] A solution of phosphinic chloride (10 mmol) in anhydrous THF (10 ml) is slowly added to Grignard solution in THF (10,5 mmol) in THF or diethyl ether. The reaction mixture is stirred under reflux for 1 h, then cooled with an ice bath and quenched with saturated aqueous ammonium chloride solution. The mixture is poured into water, acidified with diluted hydrochloric acid, extracted with chloroform. The combined extracts were washed with saturated aqueous sodium hydrocarbonate solution, brine, dried over magnesium sulfate and concentrated in vacuum to give a crude product.

[0215] Further purification could be achieved by vacuum distillation or by re-crystallization from an appropriate solvent.

Starting materials and products	
Starting compound(s)	Product
(4-bromophenyl)(methyl)phosphinic chloride	
(3-bromophenyl)(methyl)phosphinic chloride	

General procedure for OLEDs with one emission layer (single OLED),

[0216] General procedure for organic light-emitting diodes comprising of Examples 1 to 8 as well as of Comparative examples 1 to 3, comprising an organic semiconductive layer of formula (1) as electron transport layer and/ or electron injection layer and/or n-type charge generation layer.

Bottom emission devices

[0217] For bottom emission devices - Examples 1 to 8 and comparative examples 1 to 3, a 15Ω /cm² glass substrate (available from Corning Co.) with 100 nm Ag was cut to a size of 50 mm x 50 mm x 0.7 mm, ultrasonically cleaned with isopropyl alcohol for 5 minutes and then with pure water for 5 minutes, and cleaned again with UV ozone for 30 minutes, to prepare a first electrode.

[0218] Then, 92 wt.-% of (N4,N4"-di(naphthalen-1-yl)-N4,N4"-diphenyl-[1,1':4',1"-terphenyl]-4,4"-diamine) and 8 wt.-% of 2,2',2"-(cyclopropane-1,2,3-triylidene)tris(2-(p-cyanotetrafluorophenyl)acetonitrile) for comparative examples 1 to 3 or Biphenyl-4-yl(9,9-diphenyl-9H-fluoren-2-yl)-[4-(9-phenyl-9H-carbazol-3-yl)phenyl]-amine and 8 wt.-% of 2,2',2"-(cyclopropane-1,2,3-triylidene)tris(2-(p-cyanotetrafluorophenyl)acetonitrile) for Examples 1 to 8 was vacuum deposited on the ITO electrode, to form a HIL having a thickness of 10 nm. Then (N4,N4"-di(naphthalen-1-yl)-N4,N4"-diphenyl-[1,1':4',1"-terphenyl]-4,4"-diamine) for comparative examples 1 to 3 or Biphenyl-4-yl(9,9-diphenyl-9H-fluoren-2-yl)-[4-(9-phenyl-9H-carbazol-3-yl)phenyl]-amine for examples 1 to 8 was vacuum deposited on the HIL, to form a HTL having a thickness of 130 nm. 97 wt.-% of ABH113 (Sun Fine Chemicals) as a host and 3 wt.-% of NUBD370 (Sun Fine Chemicals) as a dopant were deposited on the HTL, to form a blue-emitting EML with a thickness of 20 nm.

Bottom emission devices comprising organic semiconductive layer as electron transport layer (ETL)

[0219] Then the organic semiconductive layer comprising compound of formula (1) is formed by depositing the compound, also named ETL matrix compound, according to Example 1 to Example 8 and Comparative examples 1 to 3 by depositing the compound from a first deposition source directly on the EML

[0220] Further, the thickness d (in nm) of the ETL can be taken from Table 3.

[0221] An optional electron injection layer is deposited directly on top of the electron transport layer. The composition and thickness of the electron injection layer can be taken from Table 3.

Bottom emission devices comprising organic semiconductive layer as electron injection layer (EIL)

[0222] Then the organic semiconductive layer comprising compound of formula (1) is formed by depositing the com-

pound, also named EIL matrix compound, according to Example 1 to Example 8 and Comparative examples 1 to 3 by depositing the matrix compound from a first deposition source and the lithium organic complex or zero-valent metal dopant from a second deposition source directly on the EML

[0223] The wt.-% of the lithium organic complex for the EIL can be taken from Table 4, whereby the wt.-% amount of the matrix compound is added to 100 wt.-%, respectively. That means, that the EIL matrix compound are added in a wt.-% amount such that the given wt.-% of the lithium organic complex for the EIL and the matrix compound of the EIL are in total 100 wt.-%, based on the weight of the EIL. Further, the thickness d (in nm) of the EIL can be taken from Table 4.

[0224] The wt.-% of the zero-valent metal dopant for the EIL can be taken from Table 5, whereby the wt.-% amount of the matrix compound is added to 100 wt.-%, respectively. That means, that the EIL matrix compound are added in a wt.-% amount such that the given wt.-% of the zero-valent metal dopant for the EIL and the matrix compound of the EIL are in total 100 wt.-%, based on the weight of the EIL. Further, the thickness d (in nm) of the EIL can be taken from Table 5.

[0225] The cathode was evaporated at ultra-high vacuum of 10^{-7} bar. Therefore, a thermal single coevaporation of one or several metals was performed with a rate of 0, 1 to 10 nm/s (0.01 to 1 Å/s) in order to generate a homogeneous cathode with a thickness of 5 to 1000 nm. The cathode electrode was formed from 100 nm aluminum.

[0226] The OLED stack is protected from ambient conditions by encapsulation of the device with a glass slide. Thereby, a cavity is formed, which includes a getter material for further protection.

[0227] The beneficial effect of inventive compounds of formula (1) on the performance of bottom emission devices can be seen in Tables 3, 4 and 5.

Top emission devices

[0228] For top emission devices, the anode electrode was formed from 100 nm silver on glass which is prepared by the same methods as described above.

[0229] Then, 92 wt.-% of biphenyl-4-yl(9,9-diphenyl-9H-fluoren-2-yl)-[4-(9-phenyl-9H-carbazol-3-yl)phenyl]-amine (CAS 1242056-42-3) and 8 wt.-% of 2,2',2''-(cyclopropane-1,2,3-triylidene)tris(2-(p-cyanotetrafluorophenyl)acetonitrile) is vacuum deposited on the ITO electrode, to form a HIL having a thickness of 10 nm. Then biphenyl-4-yl(9,9-diphenyl-9H-fluoren-2-yl)-[4-(9-phenyl-9H-carbazol-3-yl)phenyl]-amine (CAS 1242056-42-3) is vacuum deposited on the HIL, to form a HTL having a thickness of 130 nm. 97 wt.-% of ABH113 (Sun Fine Chemicals) as a host and 3 wt.-% of NUBD370 (Sun Fine Chemicals) as a dopant are deposited on the HTL, to form a blue-emitting EML with a thickness of 20 nm.

Top emission device comprising organic semiconductive layer of compound of formula (1)

[0230] The organic semiconductive layer comprising compound of formula (1) is deposited as described for bottom emission devices above.

[0231] The cathode electrode is formed from 13 nm magnesium (90 vol.-%) and silver (10 vol.-%) alloy, followed by 60 nm biphenyl-4-yl(9,9-diphenyl-9H-fluoren-2-yl)-[4-(9-phenyl-9H-carbazol-3-yl)phenyl]-amine (CAS 1242056-42-3).

[0232] The OLED stack is protected from ambient conditions by encapsulation of the device with a glass slide. Thereby, a cavity is formed, which includes a getter material for further protection.

[0233] To assess the performance of the inventive examples compared to the prior art, the current efficiency is measured under ambient conditions (20°C). Current voltage measurements are performed using a Keithley 2400 sourcemeter, and recorded in V. At 10 mA/cm² for bottom emission and 15 mA/cm² for top emission devices, a calibrated spectrometer CAS 140 from Instrument Systems is used for measurement of CIE coordinates and brightness in Candela. Lifetime LT of the device is measured at ambient conditions (20°C) and 15 mA/cm², using a Keithley 2400 sourcemeter, and recorded in hours. The brightness of the device is measured using a calibrated photo diode. The lifetime LT is defined as the time till the brightness of the device is reduced to 97 % of its initial value.

[0234] In bottom emission devices, the emission is predominately Lambertian and quantified in percent external quantum efficiency (EQE). To determine the efficiency EQE in % the light output of the device is measured using a calibrated photodiode at 10 mA/cm².

[0235] In top emission devices, the emission is forward directed, non-Lambertian and also highly dependent on the micro-cavity. Therefore, the efficiency EQE will be higher compared to bottom emission devices. To determine the efficiency EQE in % the light output of the device is measured using a calibrated photodiode at 15 mA/cm².

Technical effect of the invention

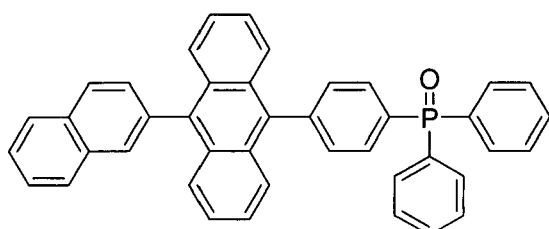
1. Bottom emission device comprising an organic semiconductive layer comprising compound of formula (1) which is free of dopant

[0236] In Table 3, the performance is shown of bottom emission devices with an organic semiconductive layer which

is free of dopant. The organic semiconductive layer has the function of an electron transport layer (ETL) and compound of formula (I) is an ETL matrix compound. The thickness of the ETL is 36 nm.

[0237] To improve electron injection, an electron injection layer is deposited on top of the electron transport layer. In comparative example 1 and examples 1 to 3, LiQ is deposited to a thickness of 1.5 nm, see Table 3.

[0238] In comparative example 1, ETL matrix compound MX 12 is used. In matrix compound MX 12 three aryl substituents are bonded to the phosphorus atom. The operating voltage is 5.25 V and the external quantum efficiency EQE is 2.5 %, see Table 3. As the efficiency is so low, the lifetime has not been measured.



MX 12

[0239] In Example 1 and 2, compounds of formula (1) have been tested as electron transport layer. In example 1, compound (f) is used as ETL matrix compound. The operating voltage is reduced to 4.5 V compared to comparative example 1. Additionally, the efficiency EQE is improved from 2.5 to 5.1 %. A reduction in operating voltage has the benefit that the energy required to operate the OLED can be reduced. Additionally, an increase in efficiency EQE is beneficial for power consumption. The OLEDs of the present invention show a significant reduction in operating voltage and/or a significant increase in efficiency EQE which is an improvement in saving electrical energy compared to the prior art. The lifetime is 17 hours. An increase in lifetime means that the device has improved stability over time.

[0240] In example 2, compound (d) is used as ETL matrix compound. The operating voltage is reduced further to 4 V and the efficiency EQE is increased further to 5.7 V. The lifetime is also much improved, see Table 3. The main difference between compounds (d) and (f) and MX 12 is the substitution pattern on the phosphorus atom. In MX 12, three aryl groups are bonded to the phosphorus atom, while in compound (f) and compound (d), two alkyl and one aryl group are bonded to the phosphorus atom.

Table 3. Bottom emission device comprising an organic semi conductive layer comprising compound of formula (1) which is free of dopant

	ETL matrix compound	ETL thickness (nm)	EIL	EIL thickness (nm)	Voltage at 10 mA/cm ² (V)	Efficiency EQE (%)	Lifetime (hours)
Comparative example 1	MX 12	36	LiQ	1.5	5.25	2.5	--
Example 1	Compound (f)	36	LiQ	1.5	4.5	5.1	17
Example 2	Compound (d)	36	LiQ	1.5	4.0	5.7	46

2. Bottom emission devices comprising an organic semi conductive layer comprising compound of formula (1) and a alkali organic complex or alkali halide

[0241] In Table 4, the performance is shown of bottom emission devices with an organic semiconductive layer comprising a compound of formula (1) and a lithium organic complex. The organic semiconductive layer has the function of an electron injection layer (EIL) and compound of formula (I) is an EIL matrix compound. The thickness of the EIL is 36 nm.

[0242] In comparative example 2, EIL matrix compound MX 12 is used. In matrix compound MX 12 three aryl substituents are bonded to the phosphorus atom. The EIL matrix compound is doped with 50 wt.-% LiQ which is a lithium organic complex. The operating voltage is 4.9 V and the external quantum efficiency EQE is 5.4 %, see Table 4. As the operating voltage is so high, the lifetime has not been measured.

[0243] In example 3, compound (b) is used as EIL matrix compound. The matrix compound is doped with the same lithium organic complex at the same concentration as in comparative example 2. The operating voltage is reduced from 4.9 to 4.6 V without detrimental impact on efficiency. The lifetime has not been measured.

[0244] In example 4, the same matrix compound is used as in example 3. However, a different lithium organic complex

is used. Li-1 is a lithium borate complex. The concentration of the lithium borate complex is 25 wt.-%. The operating voltage is further decreased to 3.6 V without detrimental impact on efficiency. The lifetime is 10 hours.

[0245] In example 5, compound (c) is tested. The same lithium organic complex is used as in example 4. The operating voltage is reduced further to 3.4 V without detrimental impact on efficiency or lifetime. Doping with lithium borate has a particularly beneficial effect on the operating voltage.

[0246] In example 6, compound (f) is tested. The same lithium organic complex is used as in comparative example 2 and example 3. The operating voltage is reduced compared to comparative example 2 and example 3. Additionally, the efficiency is increased to 6.7 % and the lifetime is exceptionally high at 130 hours (Table 4).

[0247] In summary, a substantial improvement in the performance of OLEDs is achieved through compounds of formula (1) doped with lithium organic complexes.

Table 4. Bottom emission devices comprising an organic semiconductive layer comprising compound of formula (1) and a lithium organic complex

	EIL matrix compound	Lithium organic complex	wt.-% Lithium organic complex *1	EIL thickness (nm)	Voltage at 10 mA/cm ² (V)	Efficiency EQE (%)	Lifetime (hours)
Comparative example 2	MX 12	LiQ	50	36	4.9	5.4	--
Example 3	Compound (b)	LiQ	50	36	4.6	5.3	--
Example 4	Compound (b)	Li-1	25	36	3.6	5.5	10
Example 5	Compound (c)	Li-1	25	36	3.4	5.3	9
Example 6	Compound (f)	LiQ	50	36	4.3	6.7	130
*1 the wt.-% of the matrix compound and the wt.-% of the lithium organic complex are in total 100 wt.-% based on weight of the EIL							

3. Bottom emission devices comprising an organic semiconductive layer comprising compound of formula (1) and a zero-valent metal dopant

[0248] In Table 5, the performance is shown of bottom emission devices with an organic semiconductive layer comprising a compound of formula (1) and a zero-valent metal dopant. The organic semiconductive layer has the function of an electron injection layer (EIL) and compound of formula (I) is an EIL matrix compound. The thickness of the EIL is 36 nm.

[0249] In comparative example 3, EIL matrix compound MX 12 is used. In matrix compound MX 12 three aryl substituents are bonded to the phosphorus atom. The EIL matrix compound is doped with 5 wt.-% Mg. The operating voltage is 3.8 V and the external quantum efficiency EQE is 4.8 %, see Table 5. The lifetime is 3 hours.

[0250] In example 7, compound (d) is used as EIL matrix compound. The matrix compound is doped with Mg at the same concentration as in comparative example 3. The operating voltage is reduced from 3.8 to 3.55 V, the efficiency is improved from 4.8 to 5.5 % and the lifetime is improved significantly from 3 to 56 hours.

[0251] In example 8, compound (c) is used as EIL matrix compound. The matrix compound is doped with Mg at the same concentration as in comparative example 3. The operating voltage is reduced from 3.8 to 3.5 V, the efficiency is improved from 4.8 to 6.1 % and the lifetime is improved significantly from 3 to 33 hours.

[0252] In summary, a beneficial effect is obtained when using compounds of formula (1) doped with zero-valent metal as electron injection layer.

Table 5. Bottom emission devices comprising an organic semiconductive layer comprising compound of formula (1) and a zero-valent metal dopant

	EIL matrix compound	Metal dopant	wt.-% Metal dopant *1	EIL thickness (nm)	Voltage at 10 mA/cm ² (V)	Efficiency EQE (%)	Lifetime (hours)
Comparative example 3	MX 12	Mg	5	36	3.8	4.8	3
Example 7	Compound (d)	Mg	5	36	3.55	5.5	56
Example 8	Compound (c)	Mg	5	36	3.5	6.1	33
*1 = the wt.-% of the matrix compound and the wt.-% of the Metal dopant are in total 100 wt.-% based on weight of the EIL							

4. Tandem OLED device

General procedure for OLEDs with two emission layers (tandem OLED)

[0253] For bottom emission devices, a 15Ω /cm² glass substrate (available from Corning Co.) with 100 nm ITO was cut to a size of 50 mm x 50 mm x 0.7 mm, ultrasonically cleaned with isopropyl alcohol for 5 minutes and then with pure water for 5 minutes, and cleaned again with UV ozone for 30 minutes, to prepare a first electrode.

[0254] For top emission devices, the anode electrode was formed from 100 nm silver on glass which was prepared by the same methods as described above.

[0255] Then, 92 wt.-% of Biphenyl-4-yl(9,9-diphenyl-9H-fluoren-2-yl)-[4-(9-phenyl-9H-carbazol-3-yl)phenyl]-amine (CAS 1242056-42-3) and 8 wt.-% of 2,2',2''-(cyclopropane-1,2,3-triylidene)tris(2-(p-cyanotetrafluorophenyl)acetonitrile) was vacuum deposited on the ITO electrode, to form a HIL having a thickness of 10 nm. Then Biphenyl-4-yl(9,9-diphenyl-9H-fluoren-2-yl)-[4-(9-phenyl-9H-carbazol-3-yl)phenyl]-amine was vacuum deposited on the HIL, to form a HTL having a thickness of 135 nm. 97 wt.-% of ABH113 (Sun Fine Chemicals) as a host and 3 wt.-% of NUBD370 (Sun Fine Chemicals) as a dopant were deposited on the HTL, to form a blue-emitting EML with a thickness of 25 nm.

[0256] Then, an optional hole blocking layer is deposited directly on the emission layer.

[0257] Then, the organic semi conductive layer comprising compound of formula (1) is deposited on the emission layer or hole blocking layer, if present. If the organic semiconductive layer is the n-type charge generation layer, a p-type charge generation layer consisting of 92 wt.-% of Biphenyl-4-yl(9,9-diphenyl-9H-fluoren-2-yl)-[4-(9-phenyl-9H-carbazol-3-yl)phenyl]-amine and 8 wt.-% of 2,2',2''-(cyclopropane-1,2,3-triylidene)tris(2-(p-cyano-tetrafluorophenyl)acetonitrile) was vacuum deposited on the n-type charge generation layer, to form a p-type charge generation layer having a thickness of 10 nm.

[0258] If the organic semiconductive layer is the electron transport layer, a n-type charge generation layer of compound of formula (X) is deposited on the electron transport layer, followed by the p-type charge generation layer comprising compound of formula (Y).

[0259] Then Biphenyl-4-yl(9,9-diphenyl-9H-fluoren-2-yl)-[4-(9-phenyl-9H-carbazol-3-yl)phenyl]-amine was vacuum deposited on the p-type charge generation layer, to form a HTL having a thickness of 30 nm.

[0260] Then N3,N3'-di([1,1'-biphenyl]-4-yl)-N3,N3'-dimesityl-[1,1'-biphenyl]-3,3'-diamine (CAS 1639784-29-4) was vacuum deposited on the HTL to form a triplet control layer having a thickness of 15 nm. 90 wt.-% EL-GHB914S (Samsung SDI) as a host and 10 wt.-% EL-GD0108S (Samsung SDI) as phosphorescent green emitter are vacuum deposited on the triplet control layer, to form a green emitting EML having a thickness of 30 nm. MX 11 or compound of formula (1) is vacuum deposited on the green emitting EML, to form an electron transport layer (ETL) having a thickness of 35 nm. LiQ is vacuum deposited on the ETL to form an electron injection layer (EIL) having a thickness of 2 nm. Aluminium is vacuum deposited on the EIL to form a cathode having a thickness of 100 nm.

[0261] The OLED stack is protected from ambient conditions by encapsulation of the device with a glass slide. Thereby, a cavity is formed, which includes a getter material for further projection.

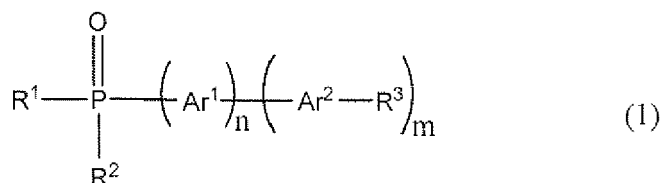
[0262] The performance is assessed as described in the general procedure for single OLEDs. Operating voltage, external quantum efficiency and/ or lifetime are improved compared to tandem OLEDs without an organic semiconductive layer comprising compound of formula (1).

[0263] From the foregoing detailed description and examples, it will be evident that modifications and variations can be made to the compositions and methods of the invention without departing from the spirit and scope of the invention.

Therefore, it is intended that all modifications made to the invention without departing from the spirit and scope of the invention come within the scope of the appended claims.

Claims

1. Organic semiconductive layer which is an electron transport layer and/or an electron injection layer and/or an n-type charge generation layer, the organic semiconductive layer comprising at least one compound of formula (1)



wherein R¹ and R² are each independently selected from C₁ to C₁₆ alkyl:

Ar¹ is selected from C₆ to C₁₄ arylene or C₃ to C₁₂ heteroarylene;

Ar² is independently selected from C₁₄ to C₄₀ arylene or C₈ to C₄₀ heteroarylene;

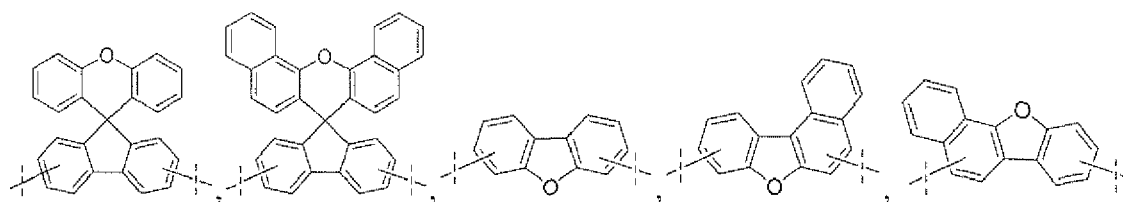
R³ is independently selected from H, C₁ to C₁₂ alkyl or C₁₀ to C₂₀ aryl;

wherein each of Ar¹, Ar² and R³ may each independently be unsubstituted or substituted with at least one C₁ to C₁₂ alkyl group;

n is 0 or 1; and

m is 1 in case of n = 0; and m is 1 or 2 in case of n = 1.

2. Organic semiconductive layer according to claim 1, wherein Ar¹ is selected from a group consisting of phenylene, biphenylene, naphthylene, fluorenylene, pyridylene, quinolinylen and pyrimidinylene.
3. Organic semiconductive layer according to claim 1 or 2, wherein Ar² is selected from a group consisting of naphthylene, fluorenylene, anthracenylene, pyrenylene, phenanthrylene, carbazoylene, benzo[c]acridinylene, dibenzo[c,h]acridinylene, dibenzo[a,j]acridinylene or from a group of the following formulas (IVa) to (IVm)



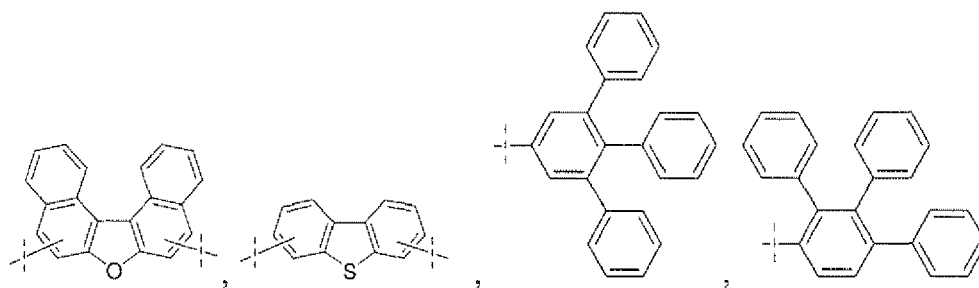
(IVa)

(IVb)

(IVc)

(IVd)

(IVe)

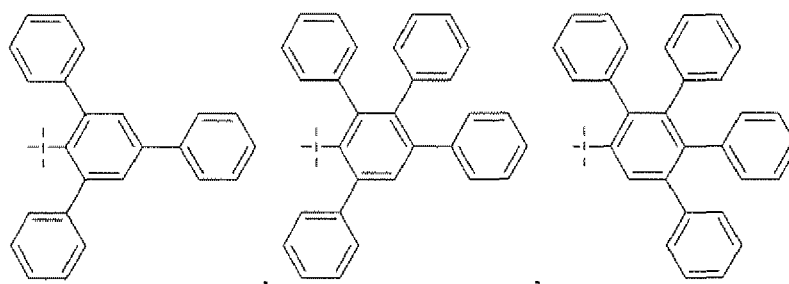


(IVf)

(IVg)

(IVh)

(IVi)

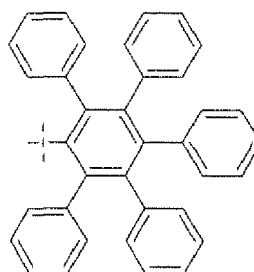


(IVj)

(IVk)

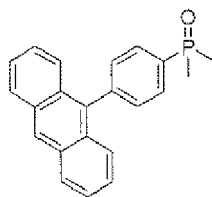
(IVl)

and

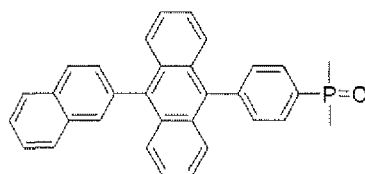


(IVm).

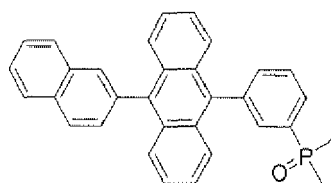
4. Organic semiconductive layer according to any of the claims 1 to 3, wherein Ar² is selected from a group consisting of anthracenylene, pyrenylene, phenanthrylene, benzo[c]acridinylene, dibenzo[c,h]acridinylene and dibenzo[a,j]acridinylene.
5. Organic semiconductive layer according to any of the claims 1 to 4, wherein R³ is selected from from H, phenyl, biphenyl, terphenyl, fluorenyl, naphthyl, phenanthryl, pyrenyl, carbazoyl, dibenzofuranyl or dinaphthofuranyl.
6. Organic semiconductive layer according to any of the claims 1 to 5, selected from one of the following compounds a to g.



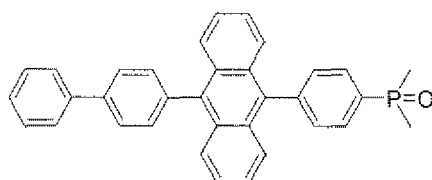
(a)



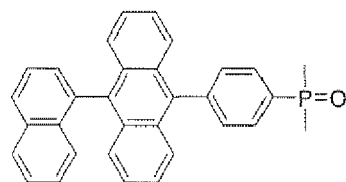
(b)



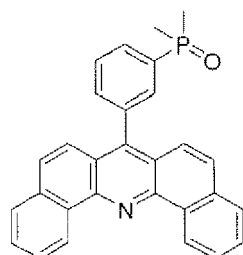
(c)



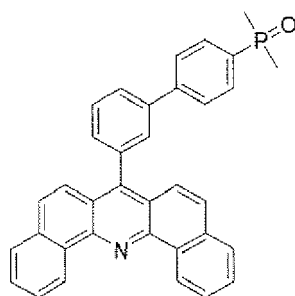
(d)



(e)

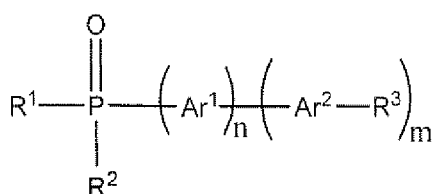


(f)



(g).

7. Organic semiconductive layer according to any of the claims 1 to 6 further comprising an alkali organic complex and/or an alkali halide.
8. Organic semiconductive layer according to any of the claims 1 to 6 further comprising a zero-valent metal dopant.
9. Organic semiconductive layer according to any of the claims 1 to 6 consisting of the at least one compound of formula (1).
10. Organic electroluminescent device comprising the organic semiconductive layer according to any of the claims 1 to 9.
11. Compound of formula (1)



(1)

wherein R^1 and R^2 are each independently selected from C_1 to C_{16} alkyl;

Ar^1 is selected from C_6 to C_{14} arylene or C_3 to C_{12} heteroarylene;

Ar^2 is independently selected from C_{14} to C_{40} arylene comprising a conjugated system of at least 14 delocalized electrons or C_8 to C_{40} heteroarylene comprising a conjugated system of at least 14 delocalized electrons;

R^3 is independently selected from H, C_1 to C_{12} alkyl or C_{10} to C_{20} aryl;

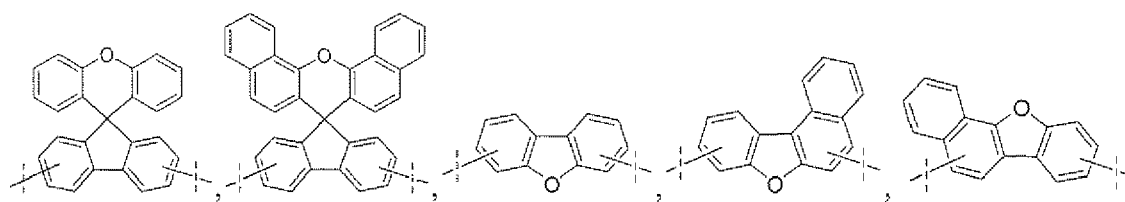
Ar^1 , Ar^2 and R^3 may each independently be unsubstituted or substituted with at least one C_1 to C_{12} alkyl group;

n is 0 or 1;

m is 1 in case of $n = 0$; and m is 1 or 2 in case of $n = 1$; and

wherein compounds with R^1 and R^2 being iso-propyl, n being 0 and Ar^2 being anthracenylene or phenanthrylene and R^3 being H are excluded.

12. Compound according to claim 11, wherein R^1 and R^2 are selected the same.
13. Compound according to claim 11 or 12, wherein Ar^1 is selected from a group consisting of phenylene, biphenylene, naphthylene, fluorenylene, pyridylene, quinolinylene and pyrimidinylene.
14. Compound according to any of the claims 11 to 13, wherein Ar^2 is selected from a group consisting of pyrenylene, carbazoylene, benzo[c]acridinylene, dibenzo[c,h]acridinylene, dibenzo[a,j]acridinylene or from a group of the following formulas (IVc) to (IVm),



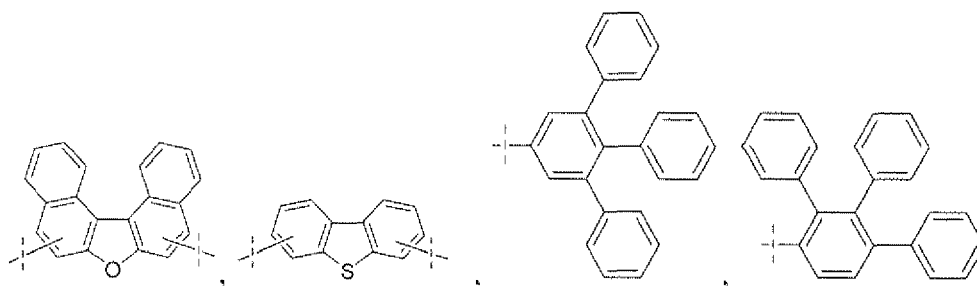
(IVa)

(IVb)

(IVc)

(IVd)

(IVe)

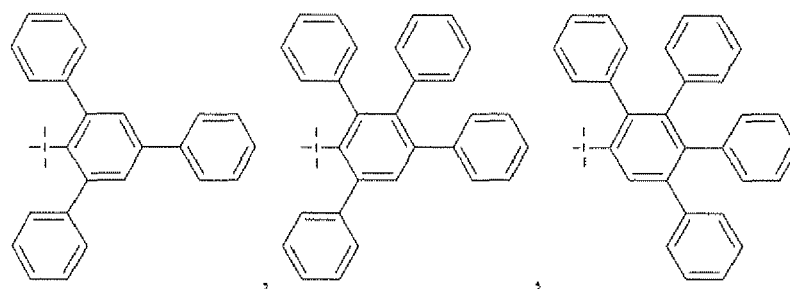


(IVf)

(IVg)

(IVh)

(IVi)

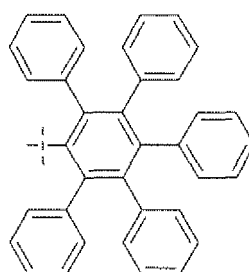


(IVj)

(IVk)

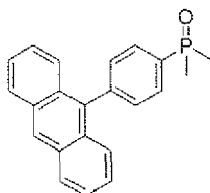
(IVl)

and

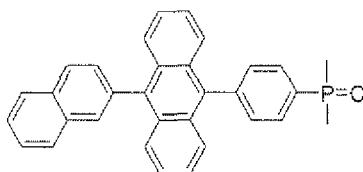


(IVm).

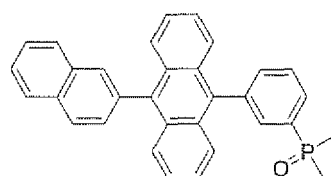
15. Compound according to any of the claim 11 to 14, wherein Ar² is selected from a group consisting of pyrenylene, benzo[c]acridinylene, dibenzo[c,h]acridinylene and dibenzo[a,j]acridinylene.
16. Compound according to any of the claims 11 to 15, wherein R³ is selected from from H, phenyl, biphenyl, terphenyl, fluorenyl, naphthyl, phenanthryl, pyrenyl, carbazoyl, dibenzofuranyl or dinaphthofuranyl.
17. Compound according to any of the claims 11 to 16, selected from one of the following compounds a to g



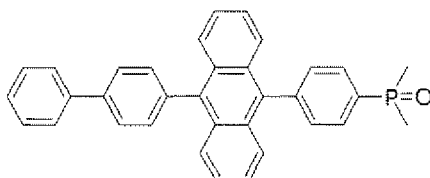
(a)



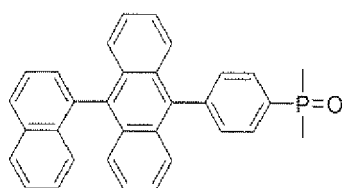
(b)



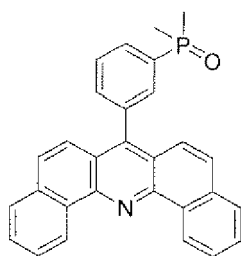
(c)



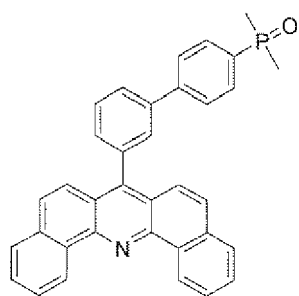
(d)



(e)



(f)



(g).

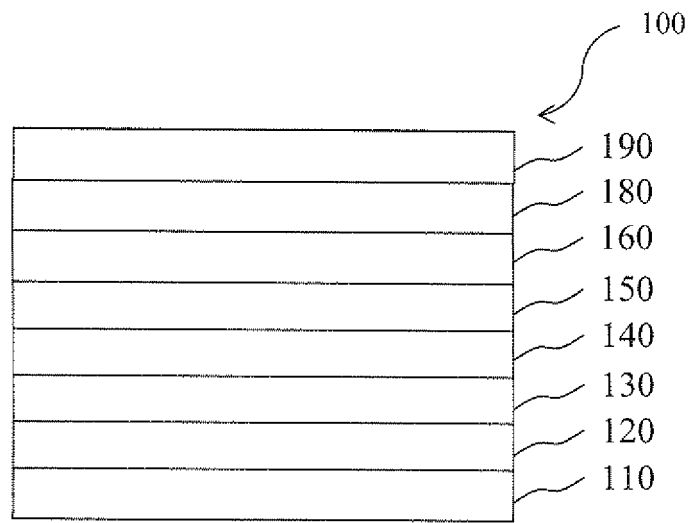


Fig.1

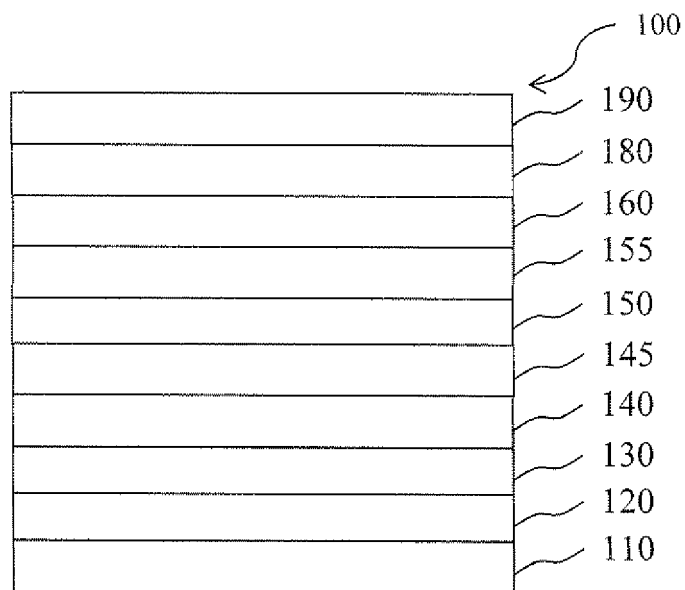


Fig.2

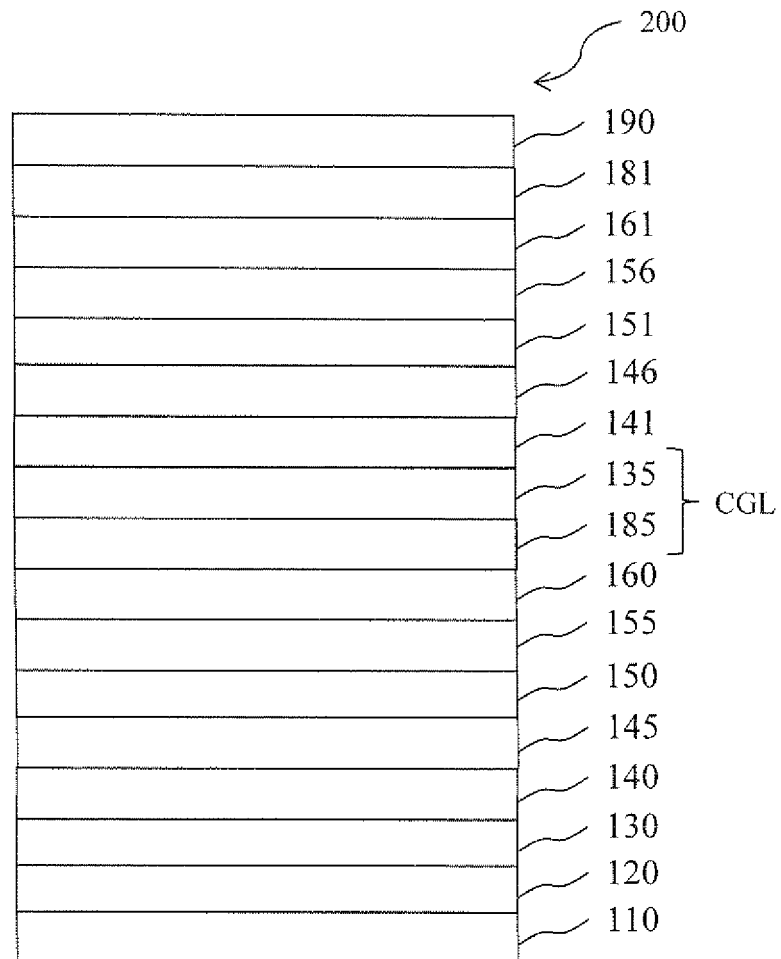


Fig.3



EUROPEAN SEARCH REPORT

 Application Number
 EP 15 19 5877

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Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (IPC)
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Y	WO 2013/079217 A1 (NOVALED AG [DE]) 6 June 2013 (2013-06-06) * page 18, line 20 - page 19, line 26 * * page 27 - page 28; compounds 23,24,34 *	7	
X	WO 03/000251 A1 (ARIAD PHARMA INC [US]; SHAKESPEARE WILLIAM C [US]; SAWYER TOMI K [US];) 3 January 2003 (2003-01-03) * paragraph [0350] *	11	
A	MASAHISA OSAWA ET AL: "Intra-Complex Energy Transfer of Europium(III) Complexes Containing Anthracene and Phenanthrene Moieties", JOURNAL OF PHYSICAL CHEMISTRY. A, MOLECULES, SPECTROSCOPY, KINETICS, ENVIRONMENT AND GENERAL THEORY, vol. 113, no. 41, 15 October 2009 (2009-10-15), pages 10895-10902, XP055272743, US ISSN: 1089-5639, DOI: 10.1021/jp905160w * page 10895, column 2, line 1 - line 5; compounds 2,3 *	1,11	TECHNICAL FIELDS SEARCHED (IPC) H01L C07F
The present search report has been drawn up for all claims			
Place of search Munich		Date of completion of the search 18 May 2016	Examiner Pusch, Catharina
CATEGORY OF CITED DOCUMENTS X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document		T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons & : member of the same patent family, corresponding document	

EPO FORM 1503 03.82 (P04C01)



EUROPEAN SEARCH REPORT

 Application Number
 EP 15 19 5877

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DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (IPC)
A	YOON JHIN-YEONG ET AL: "Synthesis and electroluminescent properties of anthracene derivatives containing electron-withdrawing oxide moieties", MATERIALS RESEARCH BULLETIN, vol. 58, 21 March 2014 (2014-03-21), pages 149-152, XP029041501, ISSN: 0025-5408, DOI: 10.1016/J.MATERRESBULL.2014.03.019 * page 150; compound 2 * * page 151, column 1, line 30 - line 36 * -----	1,11	
			TECHNICAL FIELDS SEARCHED (IPC)
The present search report has been drawn up for all claims			
Place of search Munich		Date of completion of the search 18 May 2016	Examiner Pusch, Catharina
CATEGORY OF CITED DOCUMENTS X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons & : member of the same patent family, corresponding document			

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ON EUROPEAN PATENT APPLICATION NO.**

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The members are as contained in the European Patent Office EDP file on
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18-05-2016

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		JP 2015506092 A	26-02-2015
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For more details about this annex : see Official Journal of the European Patent Office, No. 12/82

REFERENCES CITED IN THE DESCRIPTION

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专利名称(译)	包含氧化膦化合物的有机半导体层		
公开(公告)号	EP3171418A1	公开(公告)日	2017-05-24
申请号	EP2015195877	申请日	2015-11-23
[标]申请(专利权)人(译)	诺瓦莱德公开股份有限公司		
申请(专利权)人(译)	Novaled公司GMBH		
当前申请(专利权)人(译)	Novaled公司GMBH		
[标]发明人	SENKOVSKYY VOLODYMYR		
发明人	SENKOVSKYY, VOLODYMYR		
IPC分类号	H01L51/00 H01L51/50 C07F9/50 C07F9/53		
CPC分类号	H01L51/0052 C07F9/5325 C07F9/5765 C07F9/65068 C07F9/6521 C07F9/65517 C07F9/65522 C07F9/65586 C07F9/6561 H01L51/0056 H01L51/0058 H01L51/0067 H01L51/0072 H01L51/0073 H01L51/5072 H01L51/5076 H01L51/5092 H01L51/5278		
审查员(译)	PUSCH, 凯萨琳娜		
外部链接	Espacenet		

摘要(译)

本发明涉及有机半导体层，其是电子传输层和/或电子注入层和/或n型电荷产生层，该有机半导体层包含至少一种式(1)化合物，其中R¹和R²各自独立地选自C₁至C₁₆烷基；Ar¹选自C₆至C₁₄亚芳基或C₃至C₁₂亚杂芳基；Ar²独立地选自C₁₄至C₄₀亚芳基或C₈至C₄₀亚杂芳基；R³独立地选自H，C₁至C₁₂烷基或C₁₀至C₂₀芳基；其中Ar¹，Ar²和R³各自独立地是未取代的或被至少一个C₁-C₁₂烷基取代；n为0或1；在n = 0的情况下m为1；在n = 1的情况下，m为1或2，其中包含氧化膦化合物，并且包括这些层和化合物的有机电致发光器件。

